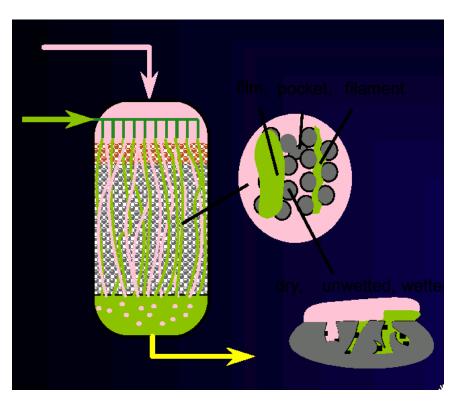
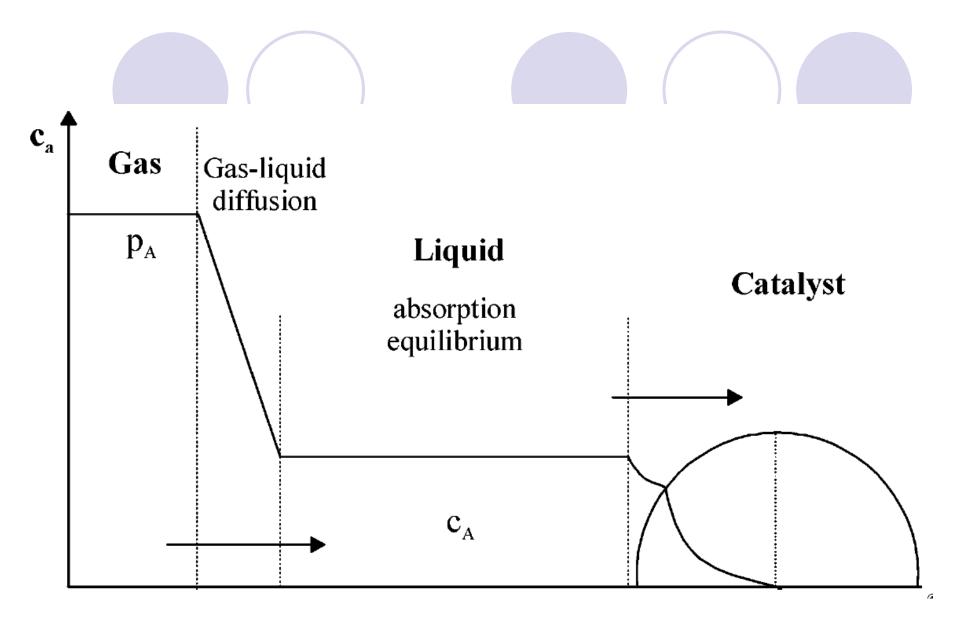
Catalytic three-phase reactors



Gas, liquid and solid catalyst

Function principle

- Some reactants and products in gas phase
- Diffusion to gas-liquid surface
- Gas dissolves in liquid
- Gas diffuses through the liquid film to the liquid bulk
- Gas diffuses through the liquid film around the catalyst particle to the catalyst, where the reaction takes place
- Simultaneous reaction and diffusion in porous particle

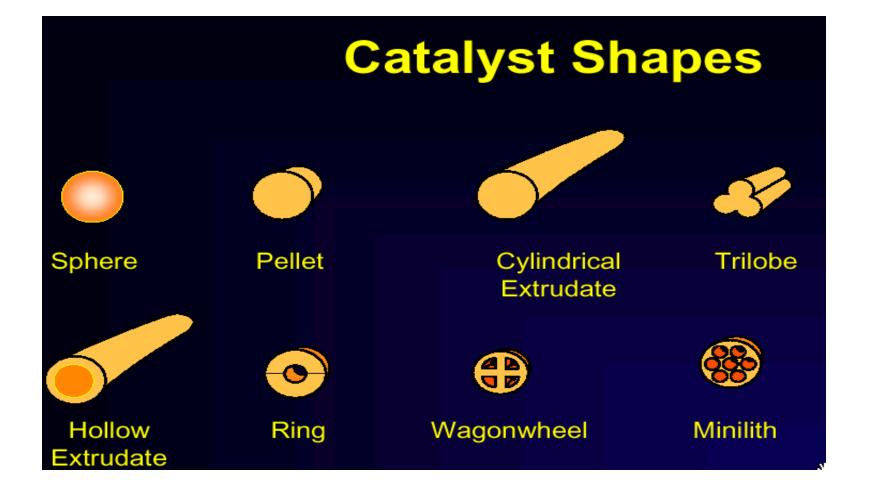


Three-phase reactors – catalyst

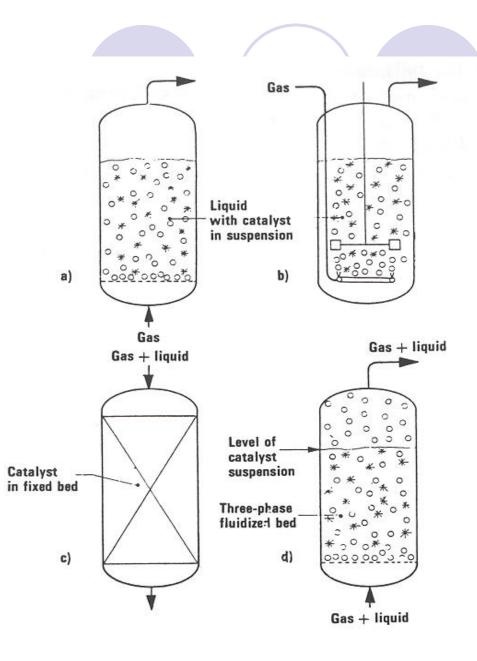
Small particles (micrometer scale < 100 micrometer)

Large particles (< 1cm)</p>

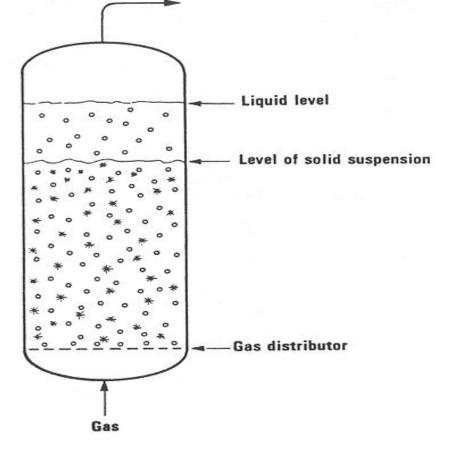
Catalyst design



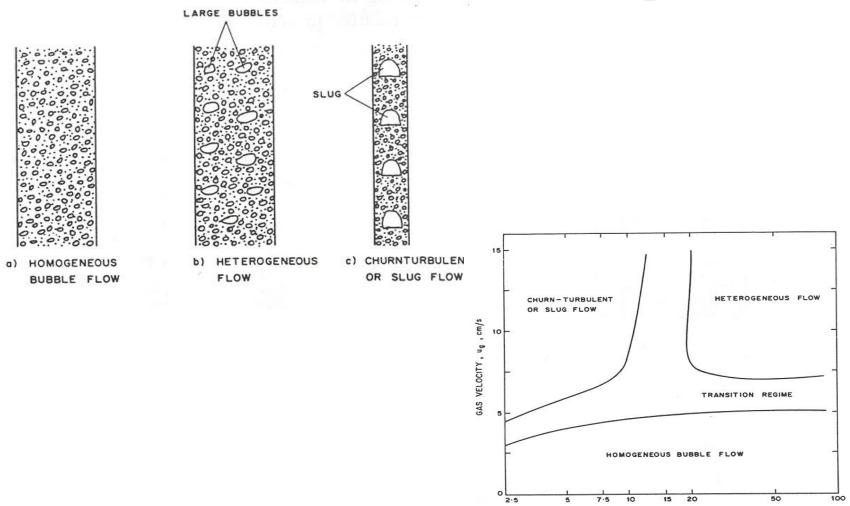
Reactors



Bubble column



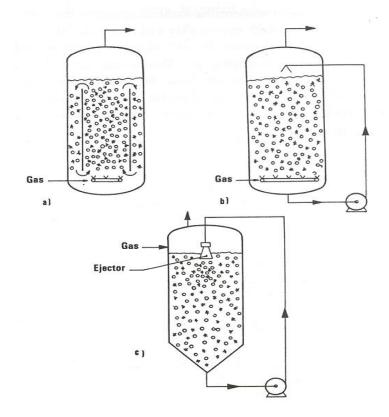
Flow pattern in bubble column



DIAMETER OF REACTOR , dT , cm

Tank reactor

Often called slurry reactor



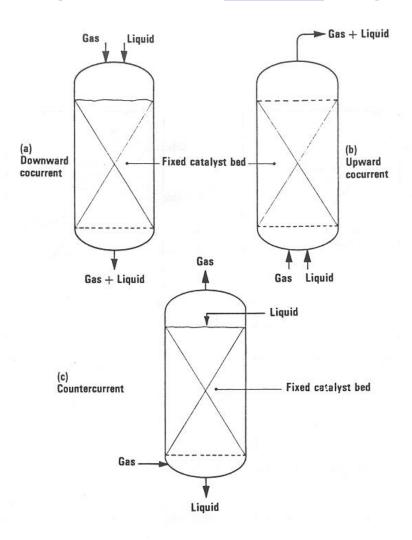
Packed bed - trickle bed

Trickle bed

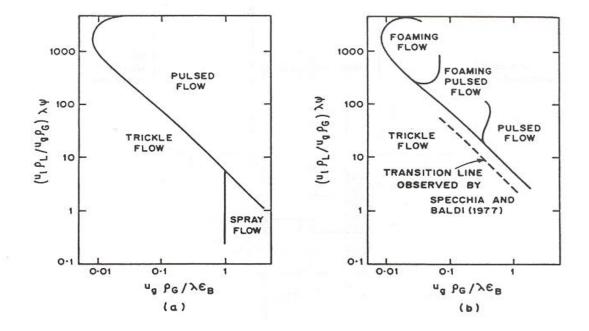
Cliquid downflow – trickling flow

Packed bed, if liquid upflow

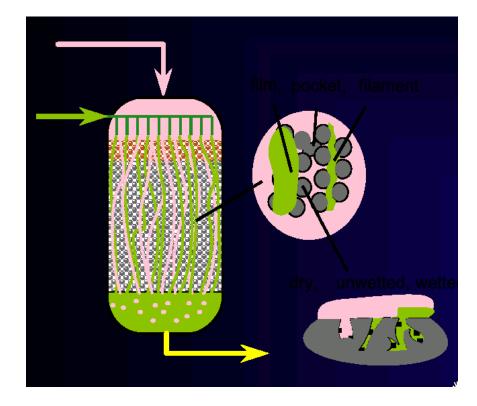
Packed bed- fixed bed - trickle bed



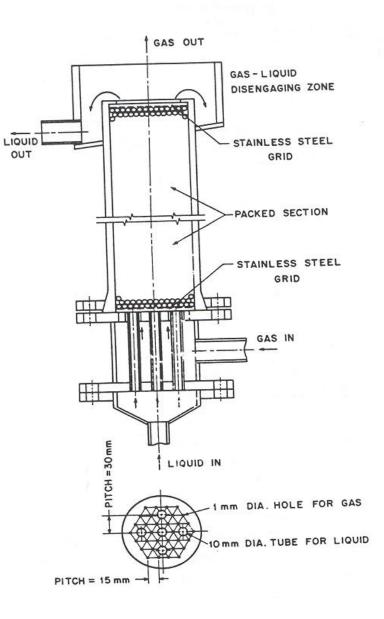
Flow chart: trickle bed



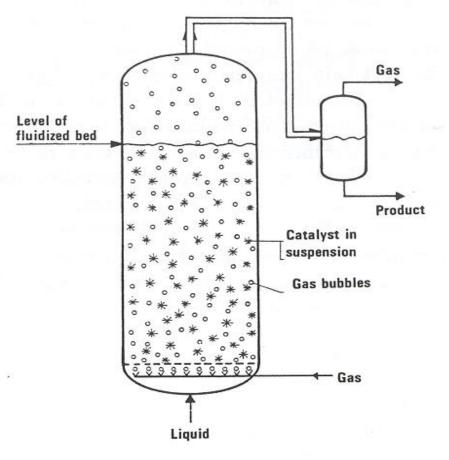
Trickle flow



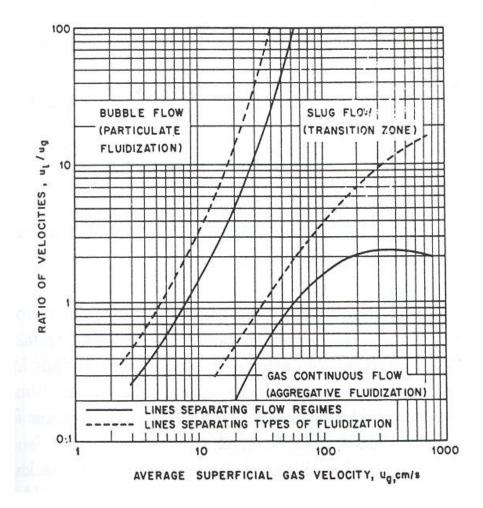
Packed bed



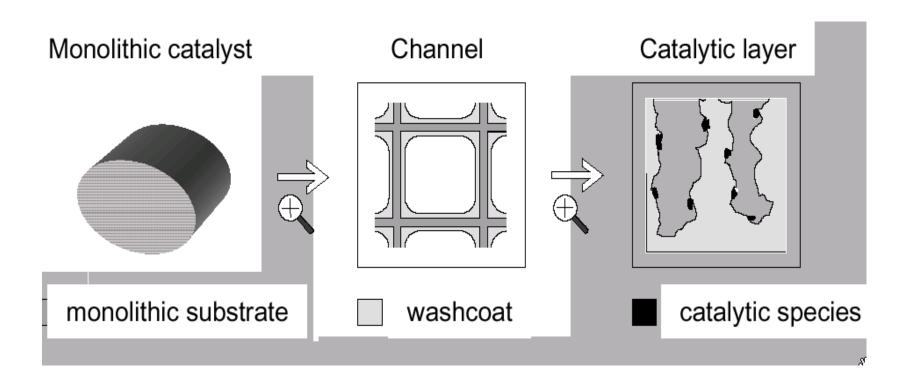
Three-phase fluidized bed



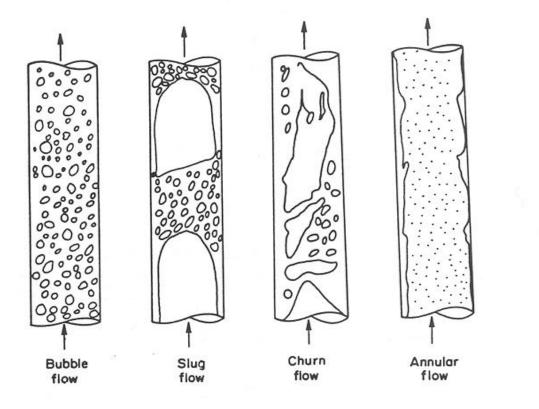
Fluidized bed - flow chart



Monolith catalysts

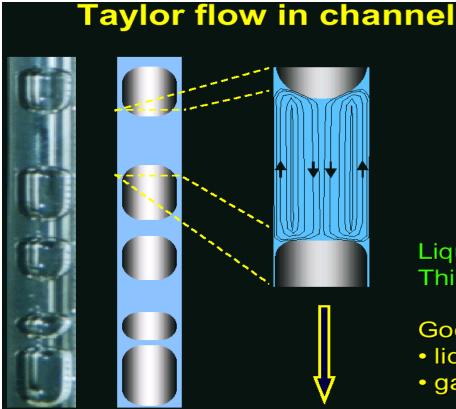


Flow in monoliths



Monolith channel



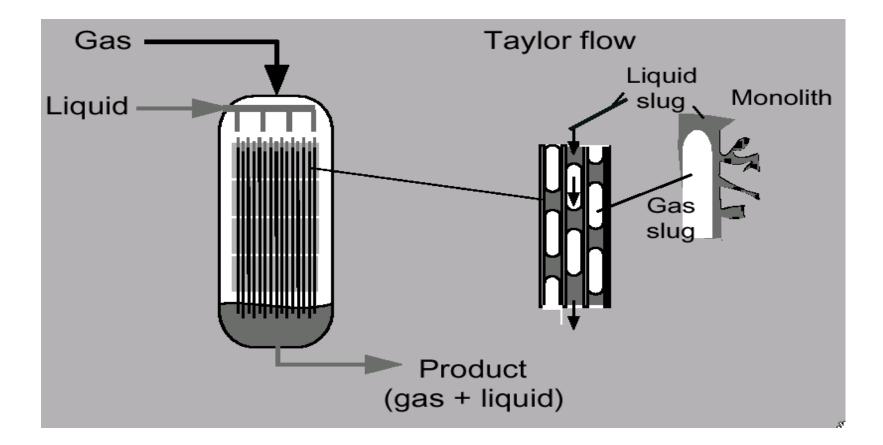


Liquid circulation Thin film

Good mass transfer • liquid - solid

• gas - solid

Three-phase monolith reactor

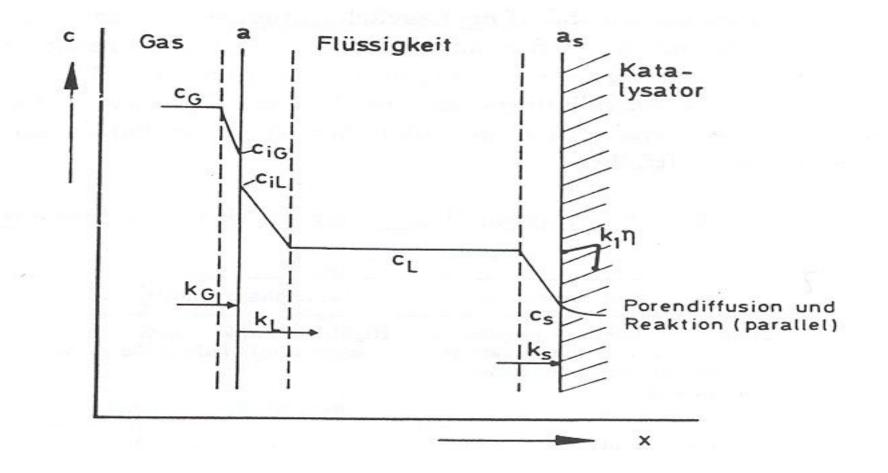


- Plug flow and axial dispersion
 - Columnr eactor
 - OTube reactor
 - OTrickle bed
 - OMonolith reactor
- Backmixing
 Bubble column
 Tank reactor

- Mass transfer from gas to liquid, from liquid to catalyst surface
- Reaction on the catalyst surface
- In gas- and liquid films only diffusion transport
- Diffusion flow from gas to liquid

$$N_{Li}^{b} = \frac{c_{Gi}^{b} - K_{i}c_{Li}^{b}}{\frac{K_{i}}{k_{Li}} + \frac{1}{k_{Gi}}}$$

Three-phase reactor Mass transfer



 For physical absorption the fluxes through the gas- and liquid films are equal

$$N_{Li}^{b} = N_{Li}^{s} = N_{Gi}^{s} = N_{Gi}^{b}$$

 Flux from liquid to catalyst particle = component generation rate at steady state

$$N_{Li}^s A_p + r_i m_p = 0$$

 Flux through the liquid film defined with concentration difference and liquid-film coefficient

$$N_{Li}^{s} = k_{Li}^{s} \left(c_{Li}^{b} - c_{Li}^{s} \right)$$

Catalyst bulk density defined by

$$\rho_B = \frac{m_{cat}}{V_L} = \frac{m_{cat}}{\varepsilon_L V_R}$$

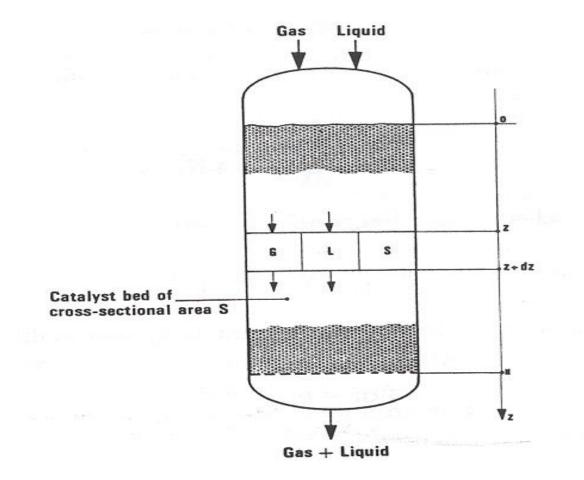
$$N_{Li}^{s} = k_{Li}^{s} \left(c_{Li}^{b} - c_{Li}^{s} \right) a_{p} = -\varepsilon_{L} \rho_{B} r_{i}$$

• a_p = total particle surface/reactor volume

- If diffusion inside the particle affects the rate, the concept of effectiviness factor is used as for two-phase reactor (only liquid in the pores of the particles)
- The same equations as for two-phase systems can be used for porous particles

$$R_{j} = \eta_{ej} R_{j}'(c_{B})$$

Three-phase reactor – plug flow



Three-phase reactor - plug flow, liquid phase

For volume element in liquid phase

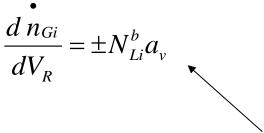
•
$$n_{Li,in} + N^b_{Li} \Delta A = n_{Li,ut} + N^s_{Li} \Delta A_p$$

Liquid phase

$$\frac{d n_{Li}}{dV_R} = N_{Li}^b a_v + N_{Li}^s a_p$$

Three-phase reactor Plug flow - gas phase • For volume element in gas phase $\dot{n}_{Gi,in} = \dot{n}_{Gi,ut} + N_{Gi}^b \Delta A$

Gas phase



- concurrent

+ countercurrent

Three-phase reactor Plug flow

- Initial conditions
 - O Liquid phase

$$\overset{\bullet}{n_{Li}} = \overset{\bullet}{n_{0,Li}} \qquad V_R = 0$$

• Gas phase, concurrent $n_{Gi} = n_{0,Gi}$ $V_R = 0$

O Gas phase, countercurrent $n_{Gi} = n_{0,Gi}$ $V = V_R$

Three-phase reactor - plug flow model

- Good for trickle bed
- Rather good for a packed bed , in which liguid flows upwards
- For bubble column plug flow is good for gas phase but not for liquid phase which has a higher degree of backmixing

Three-phase reactor - complete backmixing

Liquid phase

$$\frac{n_{Li}-n_{0Li}}{V_R} = N_L^b a_v - N_L^s a_p$$

• Gas phase
$$\frac{n_{Gi} - n_{0Gi}}{V_R} = N_L^b a_v$$

Three-phase reactor - semibatch operation

- Liquid phase in batch
- Gas phase continuous

Initial condition

$$\frac{dn_{Li}}{dt} = \left(N_L^b a_v - N_L^s a_p\right) V_R$$

$$\frac{dn_{Gi}}{dt} = -n_{Gi} - N_{Li}^b a_v V_R + n_{OGi}$$

$$n_{Li} = n_{0Li} \qquad t = 0$$
$$n_{Gi} = n_{0Gi} \qquad t = 0$$

Parameters in three-phase reactors

Gas-liquid equilibrium ratio (K_i) from
 Thermodynamic theories
 Gas solubility in liquids (Henry's constant)

Mass transfer coefficients k_{Li}, k_{Gi}

Correlation equations

$$k_{Li} = \frac{D_{Li}}{\delta_L} \qquad \qquad k_{Gi} = \frac{D_{Gi}}{\delta_G}$$

Numerical aspects

CSTR – non-linear equations Newton-Raphson method

Reactors with plug flow (concurrent)
 Runge-Kutta-, Backward difference -methods

 Reactors with plug flow (countercurrent) and reactors with axial dispersion (BVP)
 Orthogonal collocation

Examples

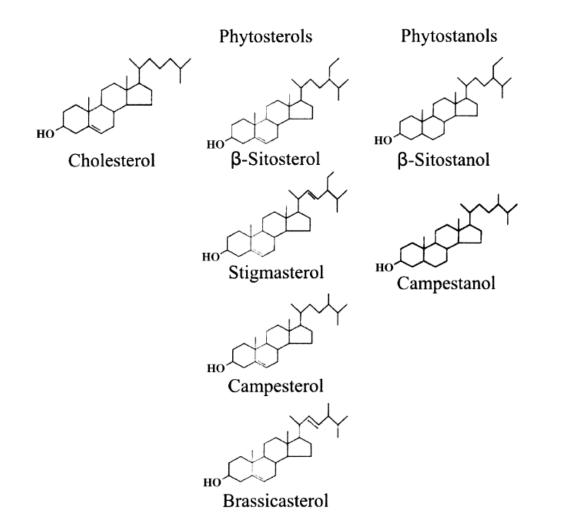
Production of Sitostanol
 A cholesterol suppressing agent
 Carried out through hydrogenation of Sitosterol

on Pd catalysts (Pd/C, Pd/Zeolite)

Production of Xylitol

 An anti-caries and anti-inflamatory component
 Carried out through hydrogenation of Xylose on Ni- and Ru-catalysts (Raney Ni, Ru/C)

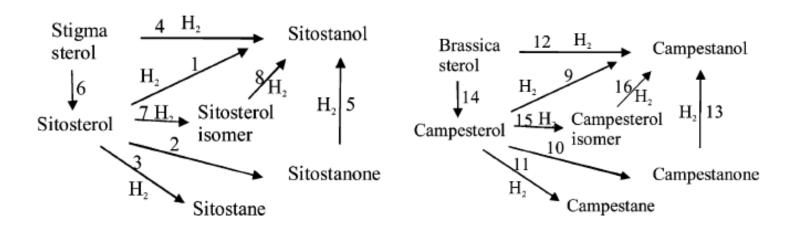
Exemple: from cholesterol tol sitostanol



Reaction scheme



A superficially complicated scheme



From laboratory scale to industrial scale

Slurry, three-phase reactor

- Lab reactor, 1 liter, liquid amount 0.5 kg
- Large scale reactor, liquid amount 8080 kg

Simulation of large-scalle reactor based on laboratory reactor

Catalytic reactor



Semi-batch stirred tank reactor

- Well agitated, no concentration differences appear in the bulk of the liquid
- Gas-liquid and liquid-solid mass transfer resistances can prevail
- The liquid phase is in batch, while gas is continuously fed into the reactor.
- The gas pressure is maintained constant.
- The liquid and gas volumes inside the reactor vessel can be regarded as constant

Mathematical modelling

Reaction, diffusion and catalyst deactivation in porous particles

film diffusion Т 6 2 pore diffusion С adsorption desorption $\Delta \rightarrow B$ surface reaction Particle model $\frac{dc_i}{dt} = \varepsilon_p^{-1} \left(r_i \rho_p - r^S \frac{d(\overline{N_i r^S})}{dr} \right)$

$$r_i = \sum_j v_{ij} R_j a_j$$

Rates

Model implementation

$$N_{i} = -D_{ei} \left(\frac{dc_{i}}{dr} \right) \quad \text{, where } D_{ei} = (\varepsilon_{p}/\tau_{p}) D_{mi}$$
$$\frac{dc_{i}}{dt} \varepsilon_{p}^{-1} = \left(\rho_{p} \sum V_{ij} R_{j} a_{j} + D_{ei} \left(\frac{d^{2}c_{i}}{dr^{2}} + \frac{s}{r} \frac{dc_{i}}{dr} \right) \right)$$

Boundary conditions

$$\frac{dc_i}{dr} = 0 \qquad r = 0$$

$$D_{ei}\left(\frac{dc_i}{dt}\right)_{r=R} = k_{Li}\left(c_i - c_i(R)\right) \qquad r = R$$

Catalytic reactor, mass balances

Liquid phase mass balance

Liquid-solid flux

Gas-liquid flux

$$\frac{dc_i}{dt} = N_i a_p - N_{GLi} a_{GL}$$

$$N_i = k_{Li} \left(c_i - c_i(R) \right)$$

$$N_{GLi} = \frac{c_{Gi}^{b} - K_{i}c_{Li}^{b}}{\frac{K_{i}}{k_{Li}} - \frac{1}{k_{Gi}}}$$

Numerical approach

- PDEs discretizied with finite difference formulae
- The ODEs created solved with a stiff algorithm (BD, Hindmarsh)

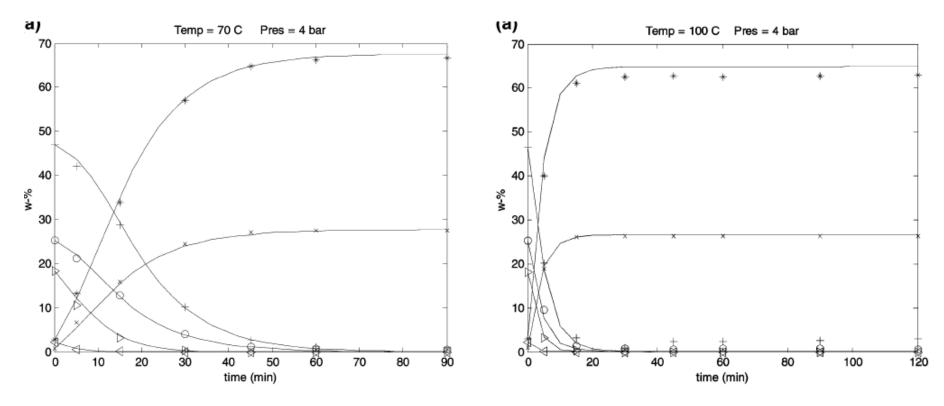
Rate equations



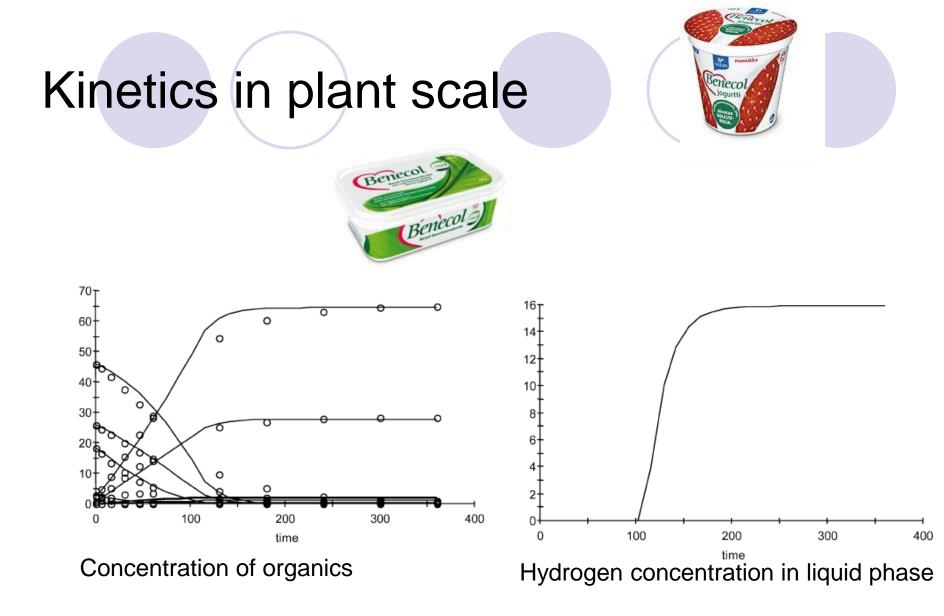
Surface reaction, rate determining Essentially non-competetive adsorption of hydrogen and organics

$$r_{j} = \frac{k_{j}' K_{\rm A} K_{\rm H_{2}} c_{j} c_{\rm H_{2}}}{(1 + \sum K_{i} c_{i})(1 + K_{\rm H_{2}} c_{\rm H_{2}})}$$

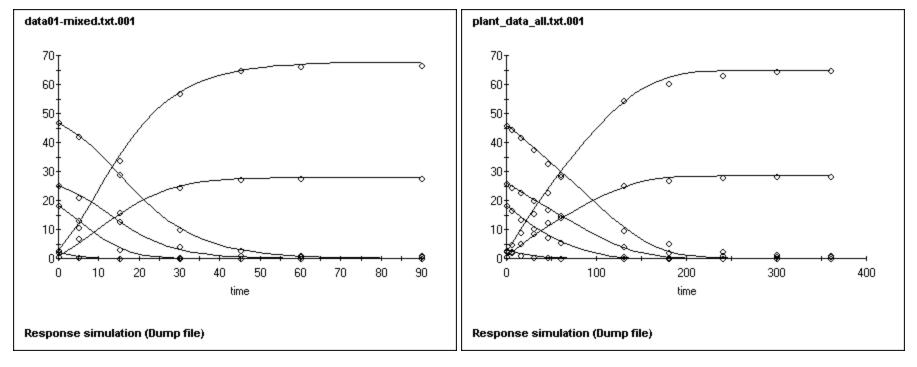
Kinetics in laboratory scale



Concentrations as a function of reaction time



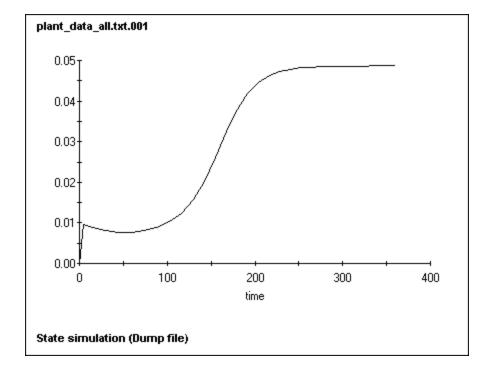
Comparison of lab and plant scale



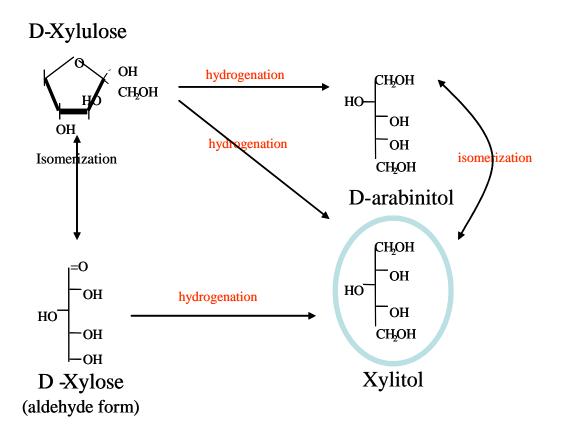
Laboratory

Factory

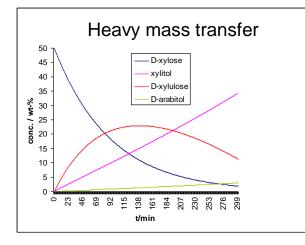
Hydrogen concentration in liquid phase in plant scale

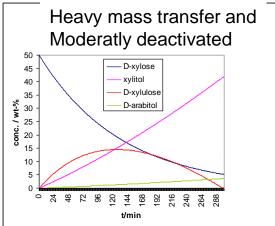


Hydrogenation of Xylose

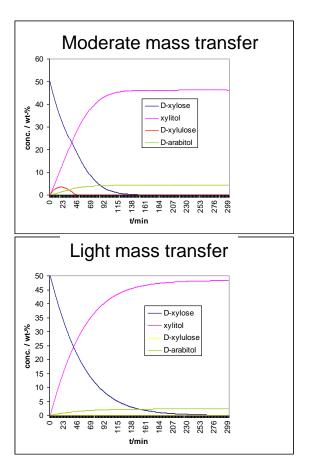


Modelling results Xylose hydrogenation

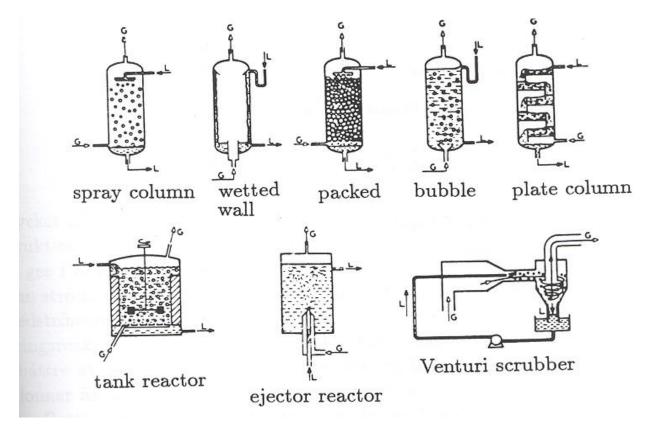




Effect of external mass transfer



Gas-liquid reactors



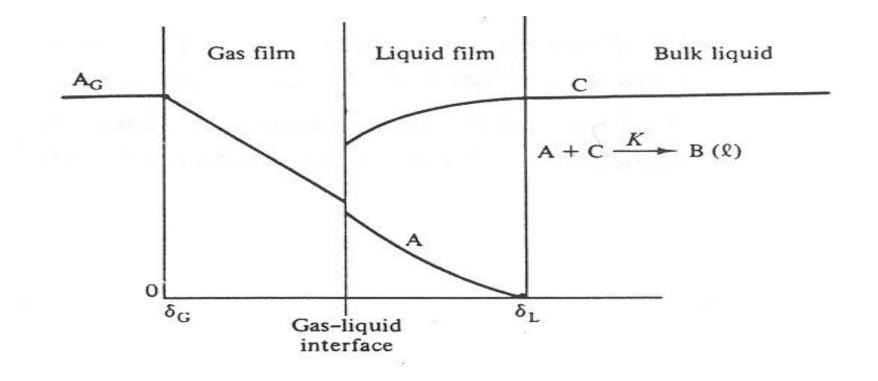
Gas-liquid reactors

- Non-catalytic or homogeneously catalyzed reactions
 - Gas phase
 - OLiquid phase (+ homogeneous catalyst)
- Components i gas phase diffuse to the gas-liquid boundary and dissolve in the liquid phase
- Procukt molecules desorb from liquid to gas or remain in liquid

Gas-liquid reactions

- Synthesis of chemicals
- Gas absorption, gas cleaning
- Very many reactor constructions used, depending on the application

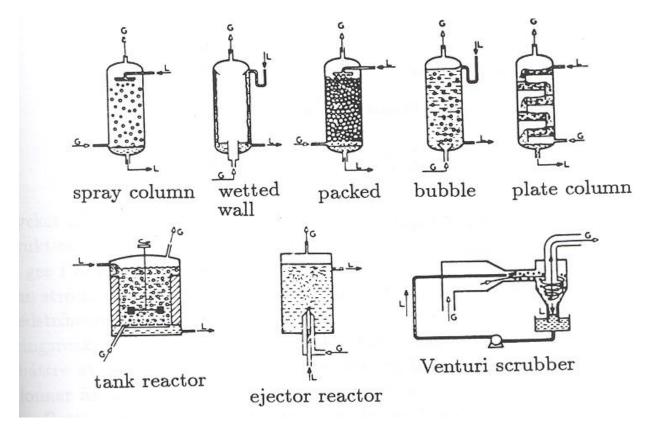
Gas-liquid reaction: basic principle



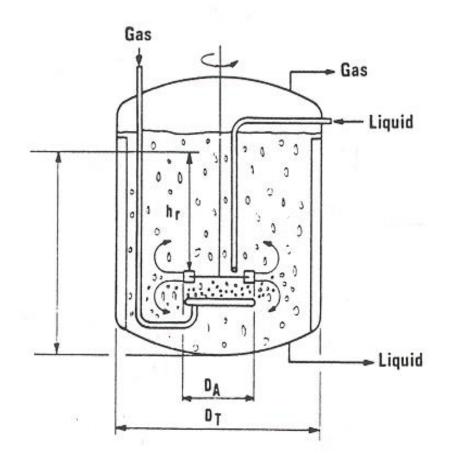
Gas-liquid reactor constructions

- Spray column
- Wetted wall column
- Packed column
- Plate column
- Bubble columns
- Continuous, semibatch and batch tank reactors
- Gas lift reactors
- Venturi scrubbers

Gas-liquid reactors - overview



Tank reactor



Gas-liquid reactors

Packed column

- OAbsorption of gases
- Countercurrent principle: gas upwards, liquid downwards

Column packings

- enable a large gas-liquid contact area
- made of ceramics, plastics or metal
- good gas distribution because of packings
- channeling can appear in liquid phase; can be handled with distribution plates
- OPlug flow in gas and liquid phases

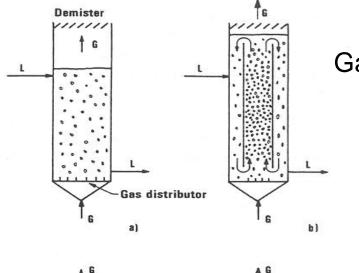
Gas-liquid reactors

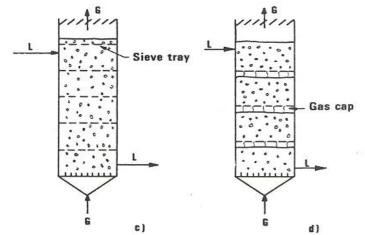
Plate column

- Absorption of gases
- Countercurrent
- Various plates used as in distillation, e.g.
 - Bubble cap
 - Plate column

- Packed column
 - Absorption of gases
 - Countercurrent
 - A lot of column packings available; continuous development

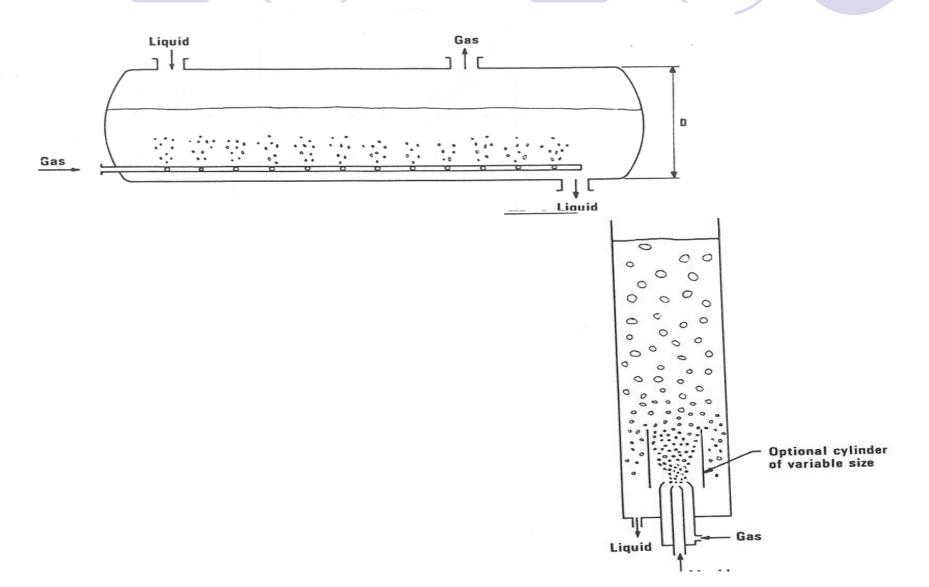
Bubble column



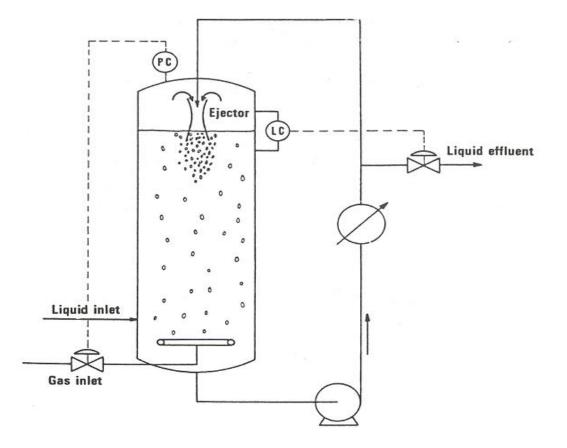


Gas-lift -reactor

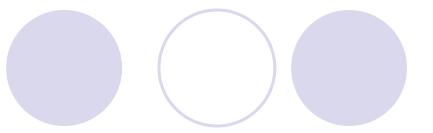
Bubble column – design examples

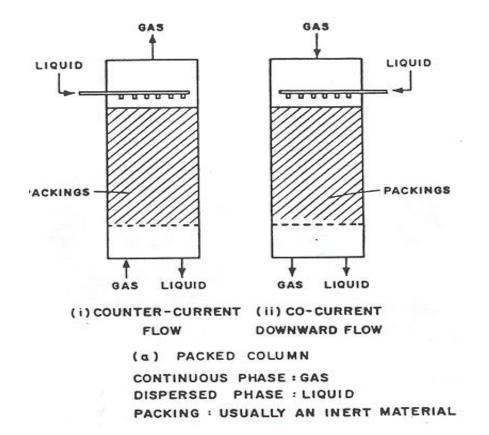


Bubble column



Packed column





Packings





Miniring



Raschig ring



Lessing ring



Berl saddle



Intalox ring

R

Intalox

saddle

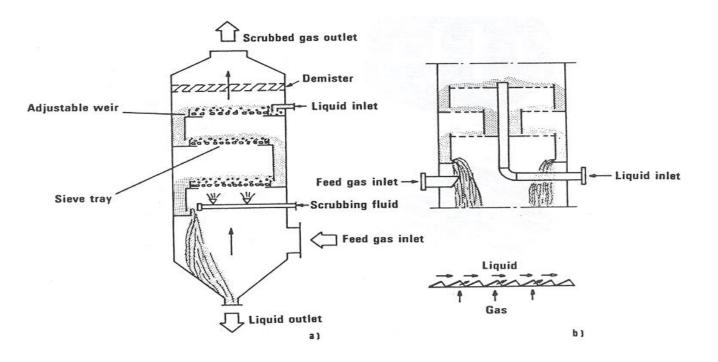


Tellerette



Pall ring

Plate column



Gas-liquid reactors

Gas scrubbers

OSpray tower

Gas is the continuous phase

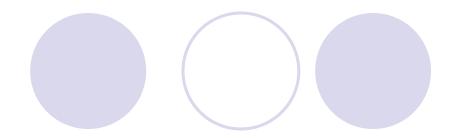
In shower !

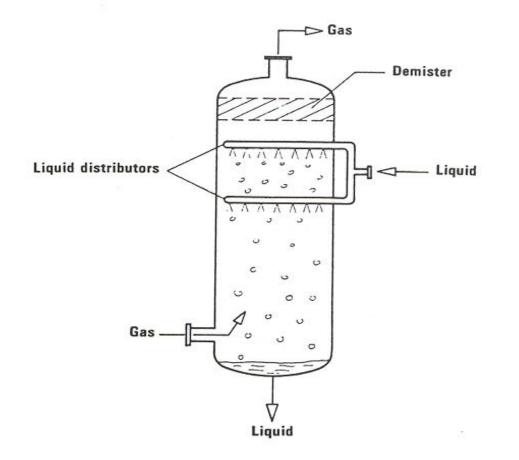
O Venturi scrubber

Liquid dispergation via a venturi neck

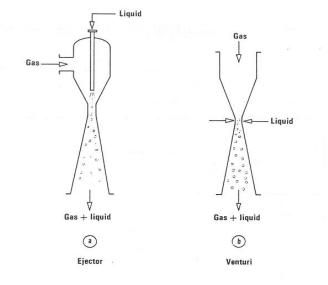
For very rapid reactions

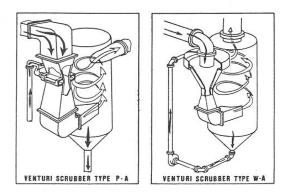
Spray tower





Venturi scrubber





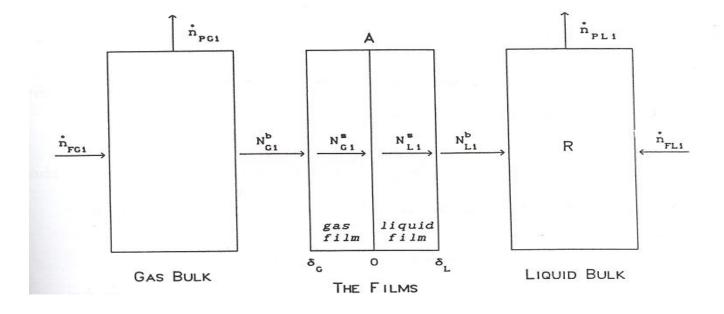
Technological details of Venturi scrubbers. Type PA, with liquid injection by nozzles. Type WA, with liquid stripping at neck.

Gas-liquid reactors

- Selection criteria
 - OBubble columns for slow reactions
 - OSckrubbers or spray towers for rapid reactions
 - Packed column or plate column if high reatant conversion is desired

0

Mass balances



$$N_i A = \left(\begin{array}{c} \frac{mol}{m^2 s} \end{array} \right) m^2$$

Gas-liquid reactors Mass balances

- Plug flow
 n_{Li,in} + N^b_{Li} \Delta A + r_i \Delta V_L = n_{Li,ut}
 Liquid phase $\frac{d n_{Li}}{dV_R} = N^b_{Li} a_v + \varepsilon_L r_i$
- Gas phase $\frac{d n_{Gi}}{dV_R} = \pm N_{Gi}^b a_v$
- a_v =gas-liquid surface area/reactor volume
 ε_L = liquid hold-up

Gas-liquid reactions Mass balances

Complete backmixing

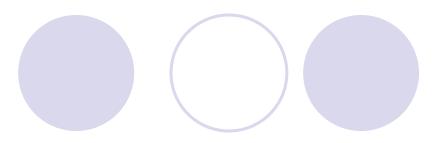
$$\bullet \\ n_{Li,in} + N^b_{Li}A + r_i V_L = n_{Li,ut}$$

Liquid phase

$$\frac{n_{Li} - n_{0Li}}{V_R} = N_{Li}^b a_v + \varepsilon_L r_i$$

- Gas phase $\frac{n_{Gi}-n_{0Gi}}{V_R} = -N_{Gi}^b a_v$ a_v =gas-liquid surface area/reactor volume
- $\epsilon_{L} =$ liquid hold-up

Gas-liquid reactors Mass balances

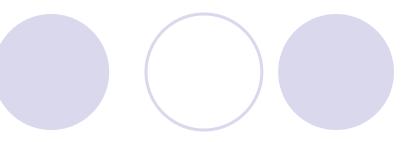


Batch reactor

$$\frac{dn_{Li}}{dt} = \left(N_{Li}^b a_v + \varepsilon_L r_i\right) V_R$$

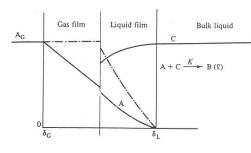
- Gas phase
- $\frac{dn_{Gi}}{dt} = -N_{Gi}^b a_v V_R$
- a_v =interfacial area/reactor volume
- $\varepsilon_L = liquid hold-up$

Gas-liquid reactors - Gas-liquid film



Fluxes in gas-liquid films

∩N^b_{Li} N^b_{Gi}



Two-film theory

Chemical reaction and molecular diffusion proceed simultaneously in the liquid film with a thickness of $\delta_{\rm L}$

Only molecular diffusion in gas film, thickness δ_{G}

Fick's law can be used:
$$N_{Gi}^{b} = +D_{Gi} \left(\frac{dc_{Gi}}{dz} \right)_{z=\delta_{G}}$$
 $N_{Li}^{b} = -D_{Li} \left(\frac{dc_{Li}}{dz} \right)_{z=\delta_{Li}}$

Gas-liquid reactors Gas film



Gas film, no reaction

$$\left(D_{Gi}\frac{dc_{Gi}}{dz}\right)_{in}A = \left(D_{Gi}\frac{dc_{Gi}}{dz}\right)_{ut}A$$

$$D_{Gi} \frac{d^2 c_{Gi}}{dz^2} = 0 \qquad N_{Gi}^b = k_{Gi} \left(c_{Gi}^b - c_{Gi}^s \right)$$

- Analytical solution possible
- The flux depends on the mass transfer coefficient and concentration difference

Gas-liquid reactors Liquid film

Diffusion and reaction in liquid film:

$$-\left(D_{Li}\frac{dc_{Li}}{dz}\right)_{in}A + r_iA\Delta z = -\left(D_{Li}\frac{dc_{Li}}{dz}\right)_{ut}A$$

$$D_{Li}\frac{d^2c_{Li}}{dz^2} + r_i = 0$$

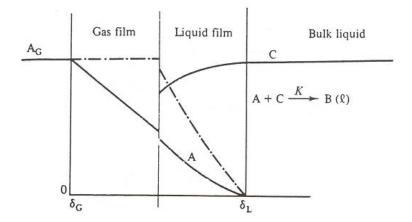
Boundary conditions:

$$N_{Gi}^{b} = N_{Li} \quad vid \quad z = 0$$
$$c_{Li} = c_{Li}^{b} \quad vid \quad z = \delta_{L}$$

Gas-liquid reactors Liquid film

Liquid film

 Equation can be solved analytically for isothermas cases for few cases of linear kinetics; in other case numerical solution should be used



Reaction categories

Physical absorption

○No reaction in liquid film, no reaction in liquid bulk

Very slow reaction

 The same reaction rate in liquid film and liquid bulk – no concentration gradients in the liquid film, a pseudo-homogeneous system

Slow reaction

 Reaction in the liquid film negligible, reactions in the liquid bulk; linear concentration profiles in the liquid film

Reaction categories

Moderate rates

Reaction in liquid film and liquid bulk

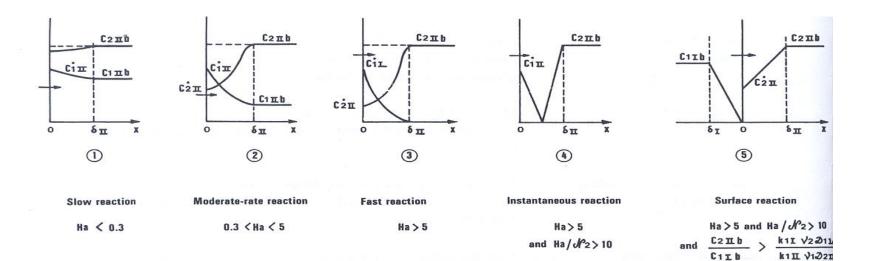
Rapid reaction

O Chemical reactions in liquid film, no reactions in bulk

Instantaneous reaction

 Reaction in liquid film; totally diffusion-controlled process

Concentration profiles in liquid film



and

Enhancement factor

Real flux/flux in the presence of pure physical absorption

$$E_{A} = \frac{N_{LA}^{s}}{\frac{c_{GA}^{b} - K_{A}c_{LA}^{b}}{\frac{K_{A}}{k_{LA}} + \frac{1}{k_{GA}}}}$$

● E_A ≥ 1

Gas-liquid reactors - very slow reaction

- No concentration gradients in the liquid film
- Depends on the role of diffusion resistance in the gas film

$$K_A = \frac{c_{GA}^s}{c_{LA}^b} \qquad K_A = \frac{c_{GA}^b}{c_{LA}^b}$$

$$N_{GA}^{b} = N_{LA}^{b} = k_{GA} \left(c_{GA}^{b} - K_{A} c_{LA}^{b} \right)$$

Gas-liquid reactors - slow reaction

 Diffusion resistance both in gas- and liquid- film retards the adsorption, but the role of reactions is negligible in the liquid film

$$N_{GA}^{b} = k_{GA} \left(c_{GA}^{b} - c_{GA}^{s} \right)$$
$$N_{LA}^{b} = k_{LA} \left(c_{LA}^{s} - c_{LA}^{b} \right)$$

$$N_{LA}^{b} = \frac{c_{GA}^{b} - K_{A}c_{LA}^{b}}{\frac{K_{A}}{k_{LA}} + \frac{1}{k_{GA}}}$$

Gas-liquid reactors - moderate rate in liquid film

Chemical reactions in liquid film



$$K_A = \frac{c_{GA}^s}{c_{LA}^s} \qquad D_{LA} \frac{d^2 c_{LA}}{dz^2} + r_A = 0$$

The transport equation should be solved numerically

Moderate rate in the liquid film

Transport equation can be solved analytically only for some special cases:

isothermal liquid film – zero or first order kinetics

Approximative solutions exist for rapid second order kinetics

Moderate rate...



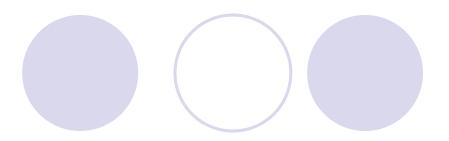
Zero order kinetics

$$\frac{d^2 c_{LA}}{dz^2} = -\frac{v_A k}{D_{LA}}$$

$$N_{LA}^{s} = \frac{c_{GA}^{b} - K_{A}c_{LA}^{b}(M-1)}{\frac{K_{A}}{k_{LA}} + \frac{1}{k_{GA}}}$$

$$M = -\frac{\nu_A k D_{LA}}{2k_{LA}^2 c_{LA}^b}$$

Moderate rate...



First order kinetics

$$\frac{d^2 c_{LA}}{dz^2} = -\frac{v_A k c_{LA}}{D_{LA}}$$

$$N_{LA}^s = \frac{c_{GA}^b - \frac{K_A c_{LA}^b}{\cosh(\sqrt{M})}}{\frac{\tanh\sqrt{M}}{\sqrt{M}} \frac{K_A}{k_{LA}} + \frac{1}{k_{GA}}} \qquad M = -\frac{v_A k D_{LA}}{k_{LA}^2} = -\frac{v_A k}{D_{LA}} \delta_L^2$$

Hatta number Ha=\sqrt{M} (compare with Thiele modulus)

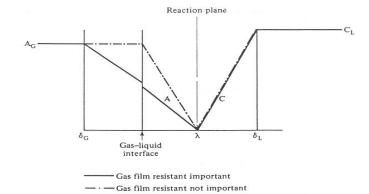
Rapid reactions

- Special case of reactions with finite rate
- All gas components totally consumed in the film; bulk concentration is zero, c^b_{LA}=0

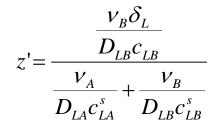
Instantaneous reactions

• Components react completely in the liquid film $D_{LA} \frac{d^2 c_{LA}}{dz^2} = 0$

A reaction plane exists



• Reaction plane coordinate $z' = \frac{D_{LB}c_{LB}}{\frac{V_A}{D_A} + \frac{V_B}{D_A}}$

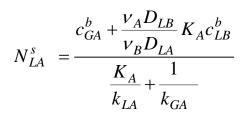


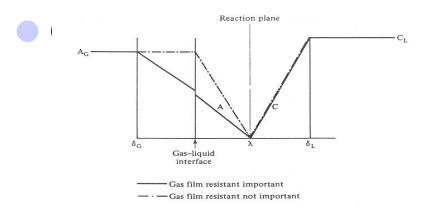
Instantaneous reactions

Enhancement factor:

 $E_A = 1 + \frac{v_A D_{LB} c_{LB}^b K_A}{v_B D_{LA} c_{GA}^b}$

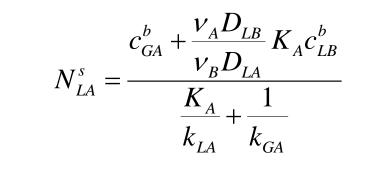
Flux at the interface:





Instantaneous reactions

Flux



- Only diffusion coeffcients affect !
- For simultaneous reactions can several reaction planes appear in the film

Fluxes in reactor mass balances

 Fluxes are inserted in mass balances

$$N_{Gi}^b = N_{Gi}^s = N_{Li}^s$$

For reactants:

$$N_{Li}^b < N_{Li}^s$$

 For slow and very slow reactions: (no reaction in liquid film)

$$N_{Li}^b = N_{Li}^s$$

General approach

We are left with the model for the liquid film:

$$D_{Li} \frac{d^2 c_{Li}}{dz^2} + r_i = 0$$

$$N_{Li}^{b} = -D_{Li} \left(\frac{dc_{Li}}{dz} \right)_{z=\delta_{Li}}$$

Solution of mass balances

• Numerical strategy:

OAlgebraic equations

Newton-Raphson method

 Differential equations, initial value problem (IVP)

Backward difference- and SI Runge-Kutta-methods

ODifferential equations, BVP

orthogonal collocation or finite differences

Number of equations

N = number of components in the system

- N eqs for liquid phase; N eqs for gas phase
- N eqs for the liquid film
- Energy balances
 - ○1 for gas phase
 - ○1 for liquid phase

3N+2 equations in total

Mass transfer coefficients

Flux through the gas film

$$N_{GA}^b = N_{GA}^s = k_{GA} \left(c_{GA}^b - c_{GA}^s \right)$$

Partial pressures often used:

$$N_{GA}^{b} = N_{GA}^{s} = k'_{GA} \left(p_{A} - p_{A}^{s} \right)$$

• Ideal gas law gives the relation: $k_{GA} = k'_{GA} RT$

Gas-liquid equilibria

Definition

$$K_A = \frac{c_{GA}^s}{c_{LA}^s}$$

For sparingly soluble gases:

- Relation becomes $He_A = \frac{p_A^s}{c_{LA}^s}$ $He'_A = \frac{p_A^s}{x_{LA}^s}$
- K_A from thermodynamics; often Henry's constant is enough He_A

$$K_A = \frac{He_A}{RT}$$

Simulation example

Chlorination of p-kresol

p-cresol + Cl₂ -> monocloro p-kresol + HCl
 monocloro p-kresol + Cl₂ -> dichloro p-kresol + HCl

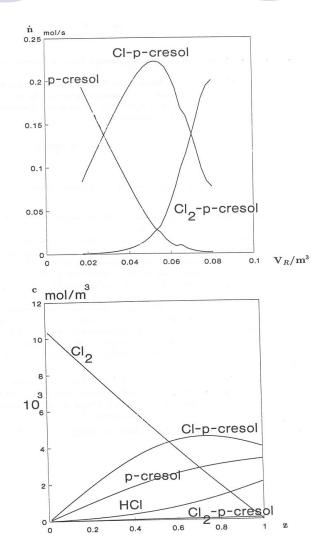
CSTR

ONewton-Raphson-iteration

Liquid film

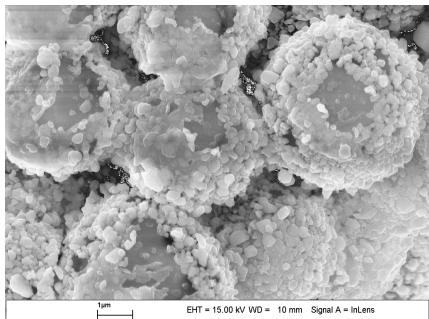
Orthogonal collocation

Chlorination of para-cresol in a CSTR



Fluid-solid reactions

- Three main types of reactions:
 - Reactions between gas and solid
 - Reactions between liquid and solid
 - Gas-liquid-solid reactions



Fluid-solid reactions

The size of the solid phase

OChanges:

Burning oc charcoal or wood

ODoes not change:

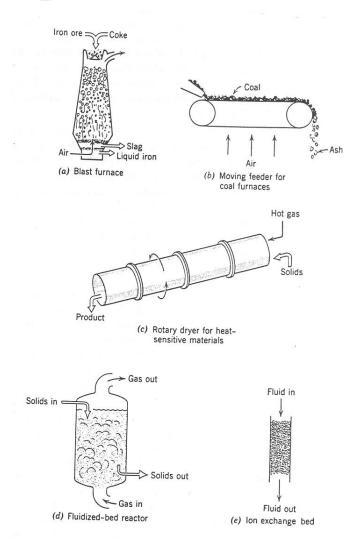
• oxidation av sulfides, e.g. zinc sulphide --> zinc oxide

Reactors for fluid-solid reactions

Reactor configurations

- Fluidized bed
- OMoving bed
- Batch, semibatch and continuous tank reactors (liquid and solid, e.g. CMC production, leaching of minerals)

Processes and reactors



Fluid-solid reaction modelling

Mathematical models used

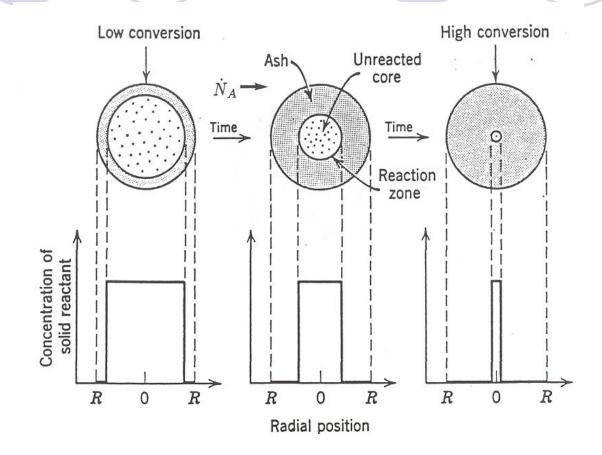
- OPorous particle model
 - Simultaneous chemical reaction and diffusion throughout the particle
- O Shrinking particle model
 - Reaction product continuously removed from the surface
- Product layer model (shrinking core model)
 - A porous product layer is formed around the non-reacted core of the solid particle
- Grain model
 - The solid phase consists of smaller non-porous particles (rasberry structure)

Fluid-solid reactions

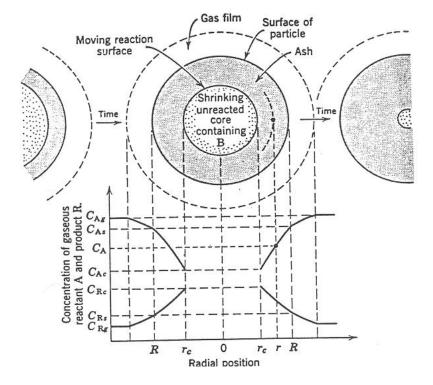
 Solid particles react with gases in such a way that a narrow reaction zone is formed

- Shrinking particle model can thus often be used even for porous particles
- Grain model most rrealistic but mathematically complicated

Product layer

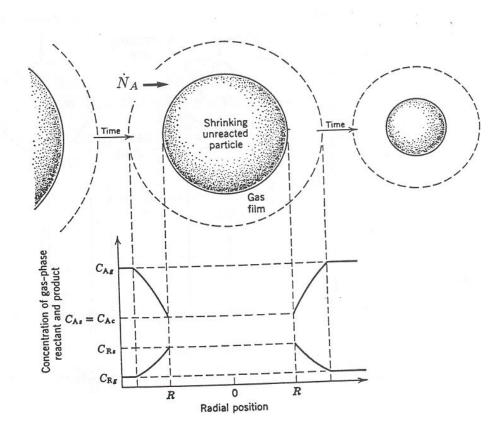


Product layer



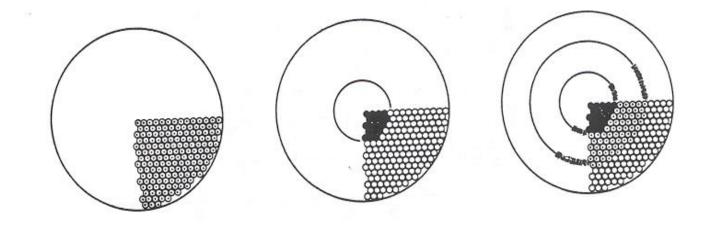
Concentration profiles in the product layer

Shrinking particle



Grain model





- Particle with a porous product layer
 - Gas or liquid film around the product layer
 - OPorous product layer
 - The reaction proceeds on the surface of nonreacted solid material
 - Gas molecules diffuse through the gas film and through the porous product layer to the surface of fresh, non-reacted material

 Reaction between A in fluid phase and B in solid phase

$$RA = ()\frac{mol}{m^2s}()m^2$$

R=reaction rate, A=particle surface area
 Generated B= Accumulated B

$$\frac{dr}{dt} = \frac{M}{x_B \rho_P} \nu_B R(c^s)$$

 Diffusion through the porous product layer (spherical particle)

$$D_{EA}\left(\frac{d^2c_A}{dr^2} + \frac{2}{r}\frac{dc_A}{dr}\right) = 0$$

• Solution gives $N_A = D_{eA}(dc_A/dr)$:

$$N_A = \frac{D_{EA}\left(c_A^b - c_A^s\right)}{r\left(1 - \frac{r}{R}\left(1 - \frac{1}{Bi_M}\right)\right)} = -v_A R(c^s)$$

 Fick's law is applied for the diffusion in the product layer gives the particle radius

$$\frac{dr}{dt} = \frac{M}{x_B \rho_p} \frac{\nu_B D_{eA} \left(c_A^b - c_A^s \right)}{\left(-\nu_A \right) r \left(1 - \frac{r}{R} \left(1 - \frac{1}{Bi_{AM}} \right) \right)}$$

Surface concentration is obtained from

$$\frac{D_{ei}\left(c_{i}^{b}-c_{i}^{s}\right)}{r\left(1-\frac{r}{R}\left(1-\frac{1}{Bi_{iM}}\right)\right)} = -\nu_{i}R(c^{s})$$

 For first-order kinetics an analytical solution is possible

Four cases – rate limiting steps

- OChemical reaction
- ODiffusion through product layer and fluid film
- ODiffusion through the product layer
- ODiffusion through the fluid film

Reaction time (t) and total reaction time (t₀) related to the particle radius (r)

- Limit cases
 - Ochemical reaction controls the process Thiele modulus is small -> Thiele modulus small
 - Diffusion through product layer and fluid film rate limiting -> Thiele modulus large

Reaktorer med reaktiv fast fas

O Diffusion through the product layer much slower than diffusion through the fluid -> Bi_{AM}= ∞

 Diffusion through fluid film rate limiting -> Bi_{AM}=0

Shrinking particle

OPhase boundary

OFluid film around particles

 Product molecules (gas or liquid) disappear directly from the particle surface

Mass balance

In via diffusion through the fluid film + generated = 0

First order kinetics

Surface reaction rate limitingDiffusion through fluid film rate limiting

Arbitrary kinetics

 A general solution possible, if diffusion through the fluid film is rate limiting

Semibatch reactor

An interesting special case

Semibatch reactor

- High throughflow of gas so that the concentrations in the gas phase can be regarded as constant; used e.g. in the investigation of gas-solid kinetics (thermogravimetric equipment)
- Complete backmixing locally
- simple realtions between the reaction time and the particle radius obtained

Reaction time and particle radius

 Thiele modulus, φ=-v_AkR/D_{eA} and Biot number, Bi_M=k_{GA}R/D_{eA}

$$\frac{t}{t_0} = \frac{6(1 - (r/R) + 3\phi(1 - (r/R)^2) - 2\phi(1 - (r/R)^3)(1 - 1/Bi_M))}{6 + \phi(1 + 2/Bi_M)}$$

- Special cases large Thiele modulus φ;
- control by product layer and fluid film

$$\frac{t}{t_0} = \frac{3(1 - (r/R)^2) - 2(1 - (r/R)^3)(1 - 1/Bi_M)}{1 + 2/Bi_M}$$

Product layer model

 Large Thiele modulus, φ=-v_AkR/D_{eA} and large Bi - control by product layer

$$\frac{t}{t_0} = 1 - 3(r/R)^2 + 2(r/R)^3$$

 Large Thiele modulus, φ=-v_AkR/D_{eA} and small Bi - control by film

$$\frac{t}{t_0} = 1 - \left(r \,/\, R\right)^3$$

- Product layer model
- Small Thiele modulus, φ=-v_AkR/D_{eA} and large Bi - control by chemical reaction

$$\frac{t}{t_0} = 1 - (r/R)$$

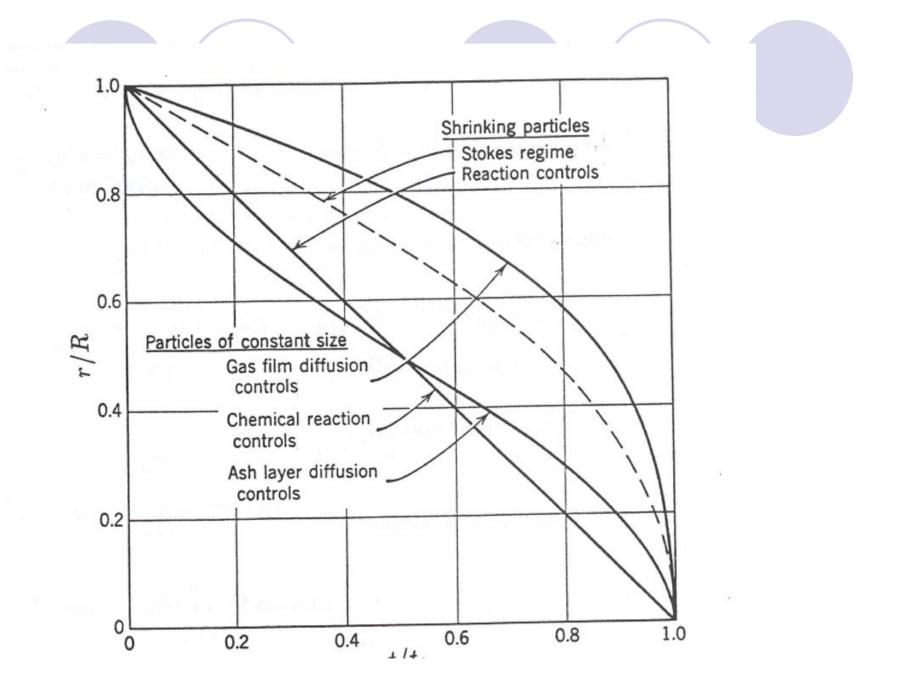
Shrinking particle model

Small Bi - control by film diffusion

$$\frac{t}{t_0} = 1 - (r/R)^2$$

Large Bi - control by chemical reaction

$$\frac{t}{t_0} = 1 - (r/R)$$

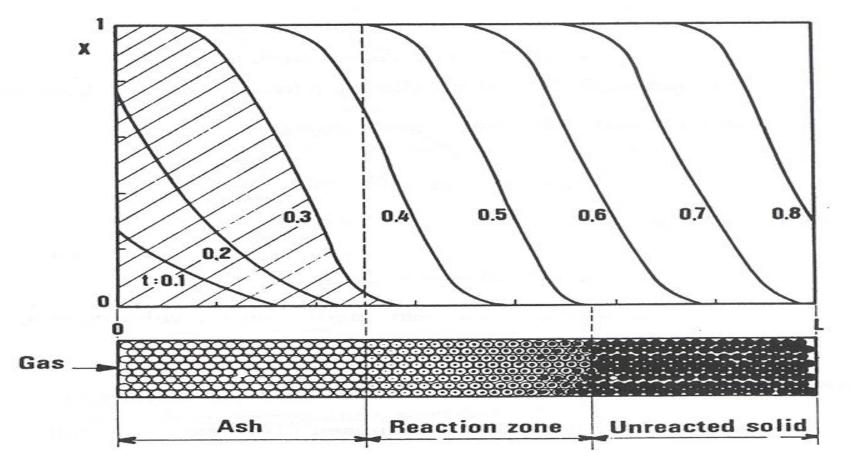


Packed bed

OPacked bed – operation principle

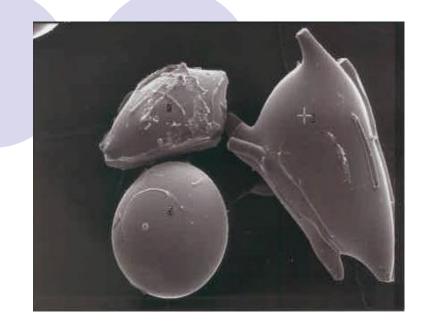
- Gas or liquid flows through a stagnant bed of particles, e.g. combustion processes or ion exchangers
- Plug flow often a sufficient description for the flow pattern
- Radial and axial dispersion effects neglected

Simulation of a packed bed



Fluid-solid reactions: the roughness of even surfaces

Tapio Salmi and Henrik Grénman



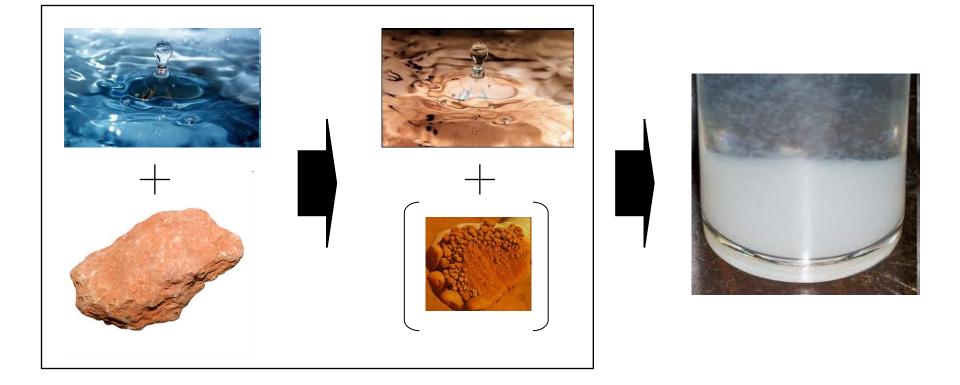
Outline

Background of solid-liquid reactions

- New methodology for solid-liquid kinetic modeling
 - Description of rough particles
 - General product layer model
 - Particle size distribution

Conclusions

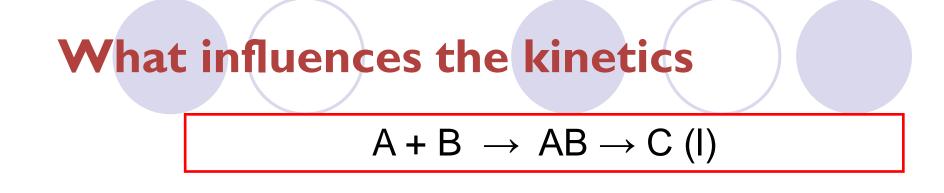
Solid-liquid reaction kinetics



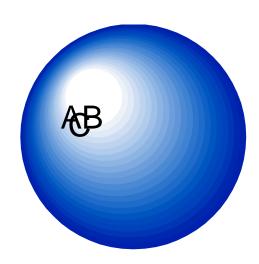
The aim is to develop a mathematical model for the dissolution kinetics

Why modeling is useful?

- Modeling helps in effective process and equipment design as well as control
- Empirical process development is slow in the long run
- The optimum is often not achieved through empirical development, at least in a reasonable time frame

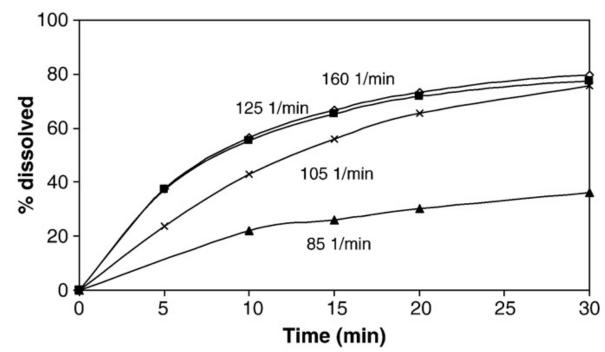


- Reaction rate depends on A
 - Mass transfer
 - External
 - Internal (often neglected)
 - Intrinsic kinetics (the "real" chemical rates



Practical influence of mass transfer

External mass transfer resistance can be overcome by agitation



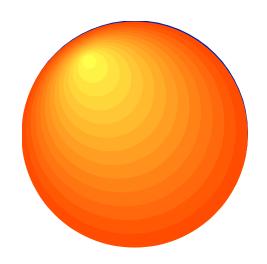
It is important to recognize what you actually are measuring

What influences the kinetics

Reaction rate depends on

Surface area of solid
 Morphological changes

Reactive surface sites on solid
 Heterogeneous solids

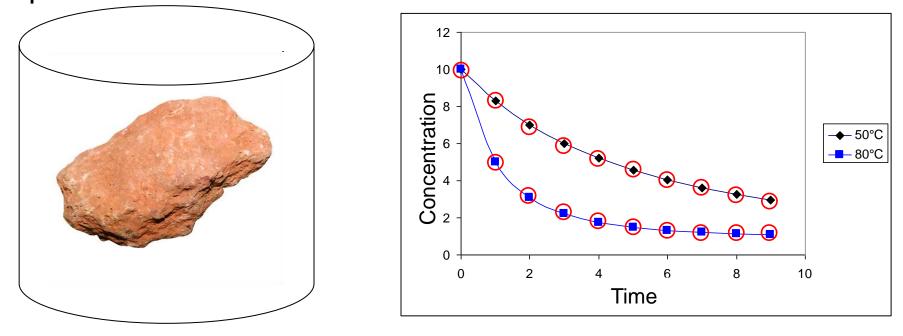


OPossible phase transformations in solid phase

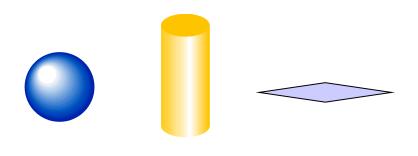
Equilibrium considerations
 Complex chemistry in liquid phase

Traditional methodology

The conversion is followed by measuring the solid or liquid phase



Traditional hypothesis in modeling solid-liquid reactions





Shrinking particle

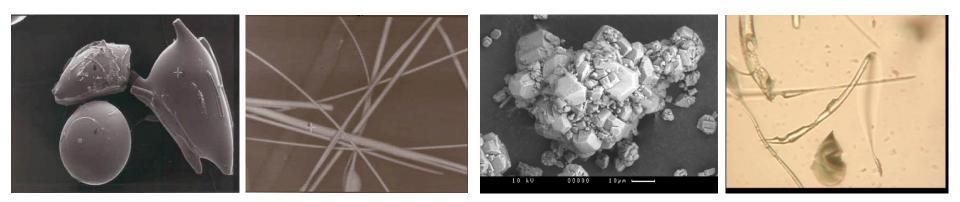
Sphere

Cylinder

Slab



Shrinking core



Traditional kinetic modeling – screening models from literature

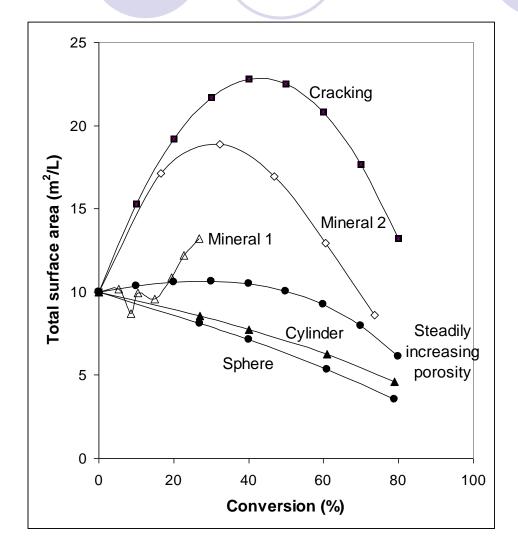
• The kinetics depends on the surface area (A) of the particles $kt = 1 - (1 - \alpha)^{1/3}$

 $\frac{dc_{solid}}{dt} = -kA_{particles}c_{liquid}^{\alpha}$

- Because of the difficulties associated with measuring the surface area on-line, the change is often expressed with the help of the conversion
- Experimental test plots are used to determine the reaction mechanism

nr	$g(\alpha)$	$f(c_{\rm S})$	Type of model
1	-ln(1-α)	$c_{\rm S}/c_{\rm 0S}$	First-order kinetics
2	$(1-\alpha)^{-1/2} - 1$	$(c_{\rm S}/c_{\rm 0S})^{3/2}$	Three-halves-order kinetics
3	$(1-\alpha)^{-1}$	$(c_{\rm S}/c_{\rm 0S})^2$	Second-order kinetics
4	$1 - (1 - \alpha)^{1/2}$	$(c_{\rm S}/c_{\rm 0S})^{1/2}$	One-half-order kinetics; two-dimensional advance of the reaction interface
5	$1 - (1 - \alpha)^{1/3}$	$(c_{\rm S}/c_{\rm 0S})^{2/3}$	Two-thirds-order kinetics; three- dimensional advance of the reaction interface
6	$1 - (1 - \alpha)^{2/3}$	$(c_{\rm S}/c_{\rm 0S})^{1/3}$	One-thirds-order kinetics; film diffusion
7	$[1 - (1 - \alpha)^{1/3}]^2$	$(c_{\rm S}/c_{\rm 0S})^{2/3}/(1 - (c_{\rm S}/c_{\rm 0S})^{1/3})$	Jander; three-dimensional
8	$1 - 2\alpha/3 - (1 - \alpha)^{2/3}$	$(c_{\rm S}/c_{\rm 0S})^{1/3}/(1 - (c_{\rm S}/c_{\rm 0S})^{1/3})$	Crank-Ginstling-Brounshtein, mass transfer across a nonporous product layer
9	$[1/(1-\alpha)^{1/3}-1]^2$	$(c_{\rm S}/c_{\rm 0S})^{5/3}/(1 - (c_{\rm S}/c_{\rm 0S})^{1/3})$	Zhuravlev-Lesokhin-Tempelman, diffusion, concentration of penetrating species varies with α
10	$[1 - (1 - \alpha)^{1/2}]^2$	$(c_{\rm S}/c_{\rm 0S})^{1/2}/(1 - (c_{\rm S}/c_{\rm 0S})^{1/2})$	Jander; cylindrical diffusion
11	$1/(1-\alpha)^{1/3} - 1$	$(c_{\rm S}/c_{\rm 0S})^{4/3}$	Dickinson, Heal, transfer across the contacting area
12	$1-3(1-\alpha)^{2/3}+2(1-\alpha)$	$(c_{\rm S}/c_{\rm 0S})^{1/3}/(1 - (c_{\rm S}/c_{\rm 0S})^{1/3})$	Shrinking core, product layer (different form of Crank-Ginstling-Brounshtein)

Surface area of solid phase



- The change in the total surface area of the solid depends strongly on the morphology of the particles
- Models based on ideal geometries can be inadequate for modeling non-ideal cases
- The particle morphology can be implemented into the model with the help of a shape factor

New methodology for general shapes

• The morphology can be flexibly implemented with the help of a shape factor (*a*)

Reaction rate:

 $\frac{dc_{solid}}{dt} = -k A_{\mu articles} c^{\alpha}_{liquid}$

Reaction rate:

$$\frac{dc_{solid}}{dt} = -kc_{particles}^{1-x}c_{liquid}^{\alpha}$$

Shape factor:

$$a = \frac{A_P}{V_P} R_0$$

			\frown
Geometry	Shape factor (a)	x= I/a	(I-x
Slab	Ι	I	0
Cylinder	2	1/2	1/2
Sphere	3	1/3	2/3
Rough, porous particle	high value	→0	→I



Geometry	Shape factor (a)	x= I/a	I-x
Slab		I	0
Cylinder	2	1/2	1/2
Sphere	3	1/3	2/3
Rough, porous particle	high value	→0	→I

Often kinetics is closer to first order!

The roughness is always there, σ =1 m²/g is not a perfect sphere!

Detailed considerations give a relation between area (A), specific surface area (σ), amount of solid (n), initial amount of solid(n₀), and molar mass (M); a=shape factor

$$A = \sigma M n_0^{1/a} n^{1-1/a}$$

New methodology

The solid-liquid reaction mechanism should be considered from chemical principles, exactly like in organic chemistry!

$$\frac{dc_{prod}}{dt} = kc_{particle}^{1-x} f(c_{liquid})$$
Solid
Contribution
Contribu

The dissolution of zink with ferric iron

$$\begin{aligned} &ZnS(s) + Fe^{3+} \leftrightarrow I_1 & (I) \\ &I_1 + Fe^{3+} \leftrightarrow I_2 & (II) \\ &I_2 \leftrightarrow S(s) + 2 Fe^{2+} + Zn^{2+} & (III) \end{aligned}$$

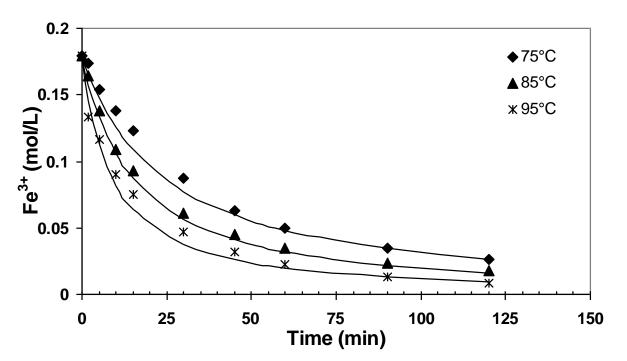
 $ZnS(s) + 2Fe^{3+} \leftrightarrow S(s) + 2 Fe^{2+} + Zn^{2+}$

The mechanism gave the following rate expression

$$r = \frac{k(c_{FeIII}^{2} - c_{FeII}^{2}c_{ZnII} / K)}{D}$$

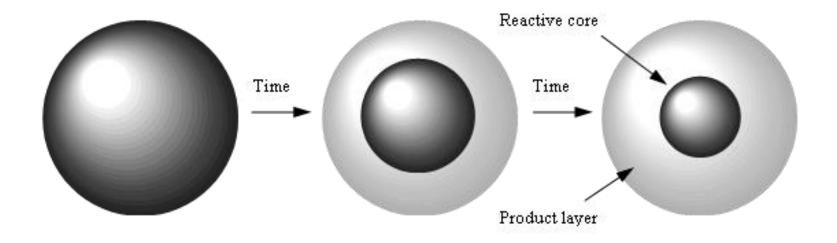
The dissolution of zink with ferric iron

The reaction order is not 2/3 but clearly higher!



Wrong reaction order in the kinetic model is the worst mistake!

General product layer model



General product layer model in a nutshell

$$\frac{(a-2)D_{ei}(c_{Li}^{\ b}-c_{Li}^{\ s})}{R(1-(1-(a-2)/Bi_{Mi})(r/R)^{a-2})(r/R)} + \sum_{k=1}^{S} v_{ik}R_k(c_{Li}^{\ s}) = 0$$

$$D_{ei}\left(\frac{d^2c_i}{dr^2} + \frac{(a-1)}{r}\frac{dc_i}{dr}\right) = 0$$

$$N_i = -D_{ei}CR^{1-a} = -k_{Li}(c_{Li}^{\ b} - c_{Li}^{\ *})$$

$$N_{i} = \frac{-(a-2)D_{ei}(c_{Li}^{b} - c_{Li}^{s})}{R(1 - (1 - (a-2)/Bi_{Mi})(r/R)^{a-2})(r/R)}$$

$$N_i A = \sum_{k=1}^{S} v_{ik} R_k(c_{Li}^{s})$$

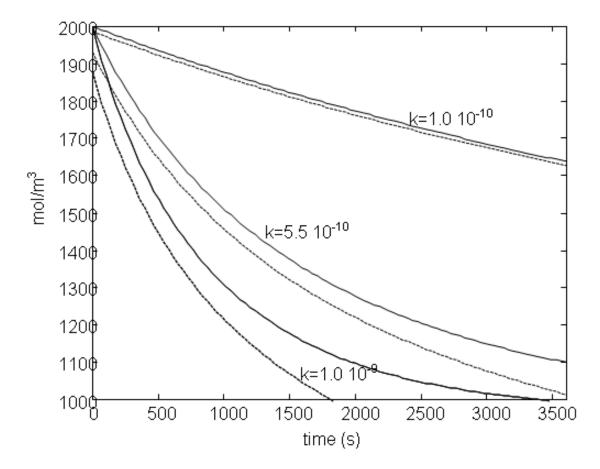
$$\frac{dn_i}{dt} = \sum_{k=1}^{S} v_{ik} R_k A$$

$$\frac{dc_j}{dt} = \frac{v_j \sigma M}{x_{0j}} c_{0j}^{x} c_j^{1-x} r$$

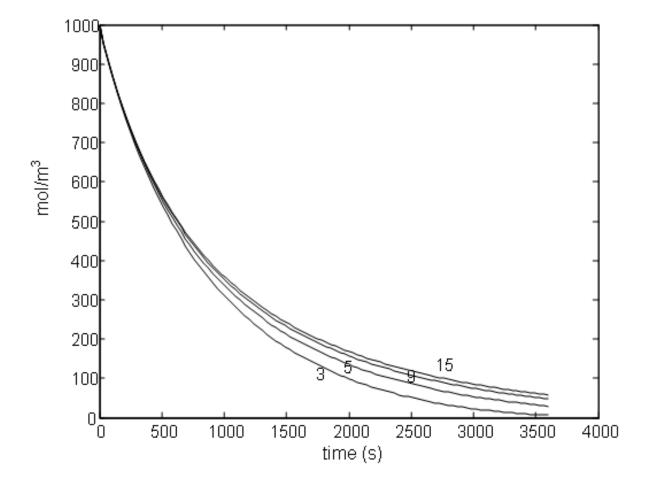
$$\frac{dc_i}{dt} = \frac{v_i \sigma M}{x_{0j}} c_{0j}^{x} c_j^{1-x} r$$

$$r = f(c_{LiS})$$

Comparison of shrinking particle and product layer model



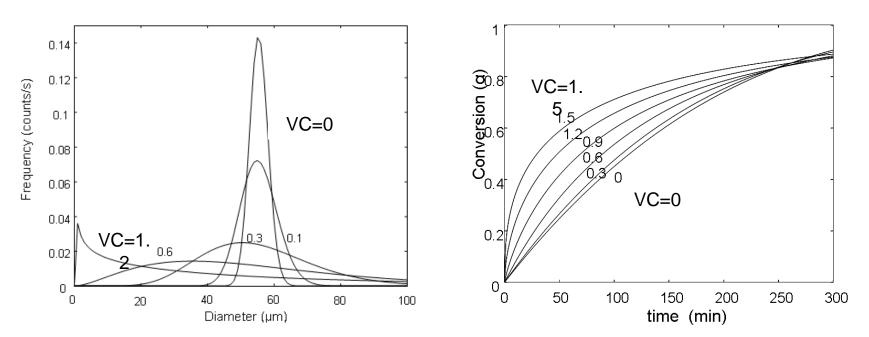
Effect of shape factor



Particle size distribution

 If the particle size distribution deviates significantly from the Gaussian distribution, erroneous conclusions can be drawn about the reaction mechanism

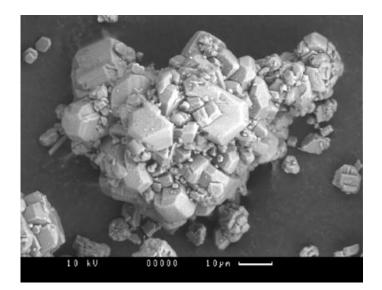
VC = standard deviation / mean particle

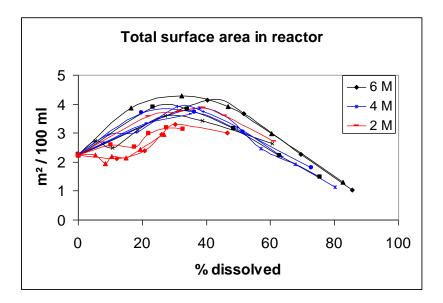


size

Shrinking sphere

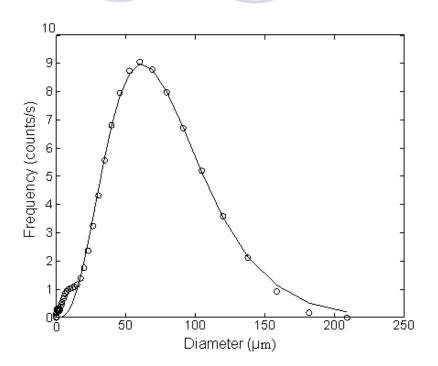
Implementing the particle size distribution into modeling





- Gibbsite is rough/porous and cracks during dissolution
- The surface area goes through a maximum, non-ideal behavior

Implementing the particle size distribution into modeling



$$f(x) = x^{k_{SP}-1} \frac{e^{-x/\theta}}{\theta^k \Gamma(k_{SP})}$$

$$\Gamma(k_{SP}) = \int_{0}^{\infty} t^{k_{SP}-1} e^{-t} dt$$

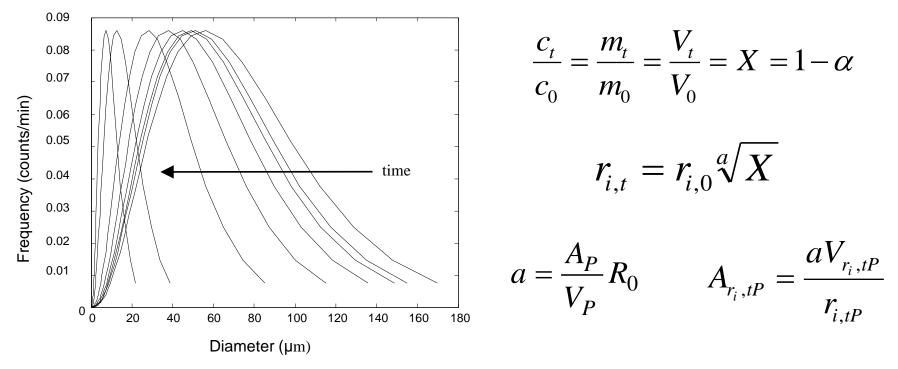
 $Var(x) = k_{SP}\theta^2$ $E(x) = k_{SP}\theta$

 The Gamma distribution is fitted to the fresh particle size distribution and

the distribution is divided into fractions

• The shape parameter (k) and the scale parameter (θ) are kept constant

Implementing the particle size distribution into modeling

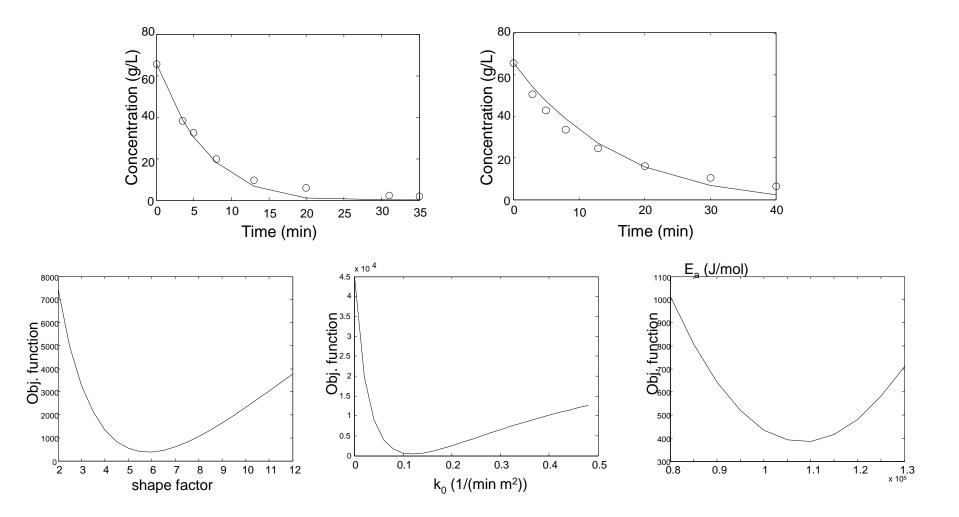


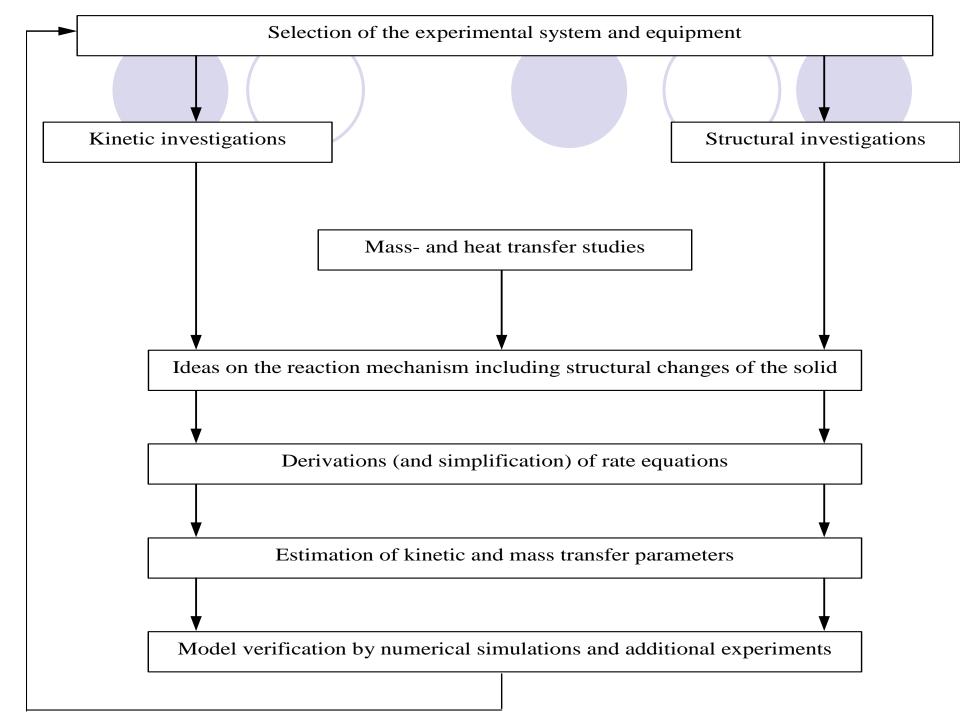
A new radius is calculated for each fraction and each fraction is summed to

obtain the new surface area in the reactor

• The new surface area is implemented into to rate equation

The fit of the model and sensitivity analysis





Conclusions



- Modeling is an important tool in developing new processes as well as optimizing existing ones
- Solid-liquid reactions are in general more difficult to model than homogeneous reactions
- Traditional modeling procedures have potholes, which can severely influence the outcome
- Care should be taken in drawing the right conclusions about the reaction mechanisms

Things to consider in modeling

- Some important factors:
 - I. Be sure about what you actually are measuring
 - 2. Evaluate if the particle size distribution needs to be taken into account (VC < 0.3)
 - 3. If the morphology is not ideal use a shape factor to describe the change in surface area (surface area, density and conversion measurements needed)
 - 4. Use sensitivity analysis to see if your parameter values are well defined

Some relevant publications

- Salmi, Tapio; Grénman, Henrik; Waerna, Johan; Murzin, Dmitry Yu. Revisiting shrinking particle and product layer models for fluid-solid reactions From ideal surfaces to real surfaces. Chemical Engineering and Processing 2011, 50(10), 1076-1084.
- Salmi, Tapio; Grénman, Henrik; Bernas, Heidi; Wärnå, Johan; Murzin, Dmitry Yu. Mechanistic Modelling of Kinetics and Mass Transfer for a Solid-liquid System: Leaching of Zinc with Ferric Iron. Chemical Engineering Science 2010, 65(15), 4460-4471.
- Grénman, Henrik; Salmi, Tapio; Murzin, Dmitry Yu.; Addai-Mensah, Jonas. The Dissolution Kinetics of Gibbsite in Sodium Hydroxide at Ambient Pressure. Industrial & Engineering Chemistry Research 2010, 49(6), 2600-2607.
- Grénman, Henrik; Salmi, Tapio; Murzin, Dmitry Yu.; Addai-Mensah, Jonas. Dissolution of Boehmite in Sodium Hydroxide at Ambient Pressure: Kinetics and Modelling. Hydrometallurgy 2010, 102(1-4), 22-30.
- Grénman, Henrik; Ingves, Malin; Wärnå, Johan; Corander, Jukka; Murzin, Dmitry Yu.; Salmi, Tapio. Common potholes in modeling solid-liquid reactions – methods for avoiding them. Chemical Engineering Science (2011), 66(20), 4459-4467.
- Grénman, Henrik; Salmi, Tapio; Murzin, Dmitry Yu.. Solid-liquid reaction kinetics experimental aspects and model development. Rev Chem Eng 27 (2011): 53–77



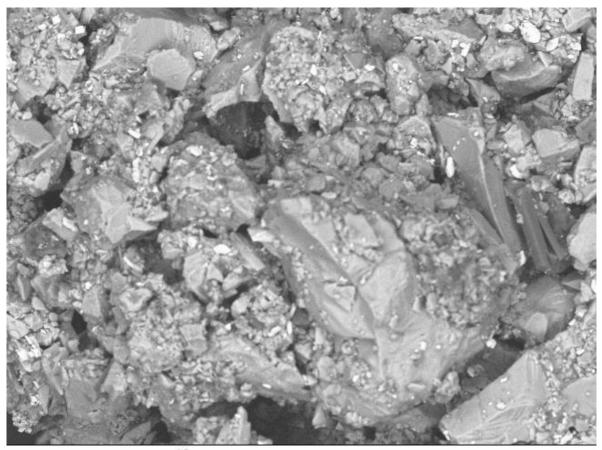
Mechanistic modelling of kinetics and mass transfer for a solid-liquid system: Leaching of zinc with ferric iron

Tapio Salmi, Henrik Grénman, Heidi Bernas, Johan Wärnå, Dmitry Yu. Murzin

Laboratory of Industrial Chemistry and Reaction Engineering, Process Chemistry Centre, Åbo Akademi, FI-20500 Turku/Åbo, Finland

Reaction system

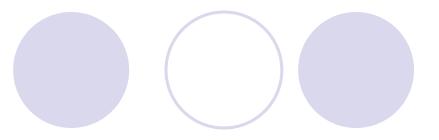
$ZnS(s) + Fe2(SO_4)_3 \leftrightarrow S(s) + 2FeSO_4 + ZnSO_4$



SEM



Experimental system

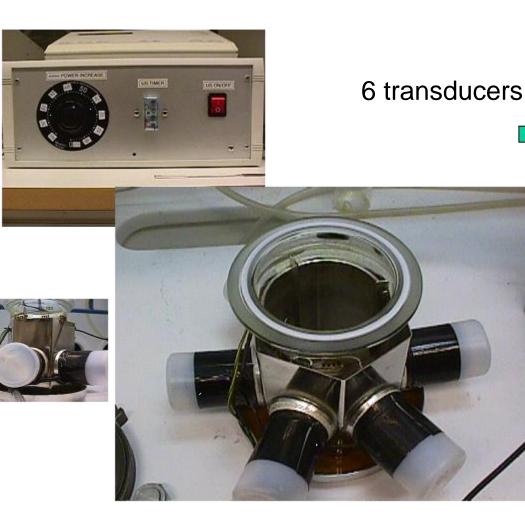


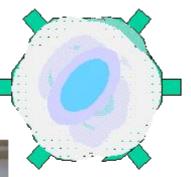
- Isothermal batch reactor
- Turbine impeller
- Ultrasound input
- SIA analysis of Fe³⁺

Experimental data of Bernas (Markus) & Grénman

Markus et al, Hydrometallurgy 73 (2004) 269-282, Grénman et al, Chemical Engineering and Processing 46 (2007) 862-869

Multi-transducer ultradound reactor

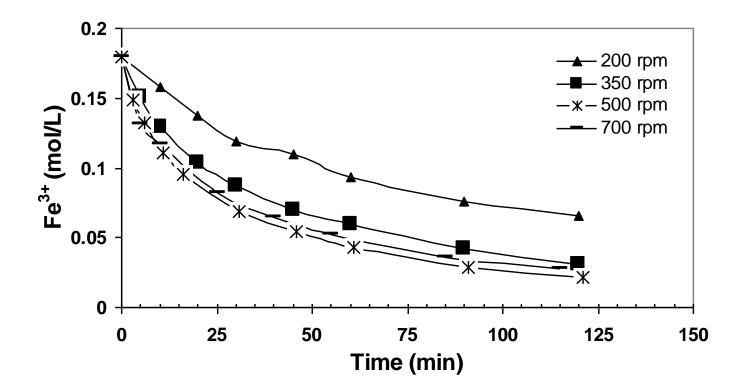




Generator (0-600W) 20 kHz Reactor pot inserted A time-variable power input

Experimental results - Stirring speed

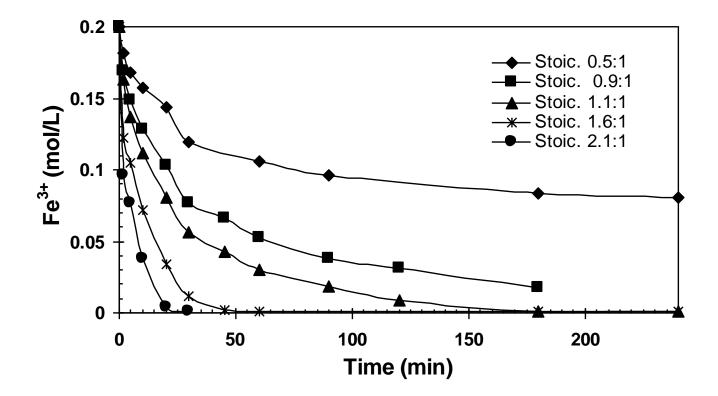
 $T = 85^{\circ}C$, Sphalerite : $Fe^{3+} = 1.1:1$



The effect of the stirring speed on the leaching kinetics.

Experimental results

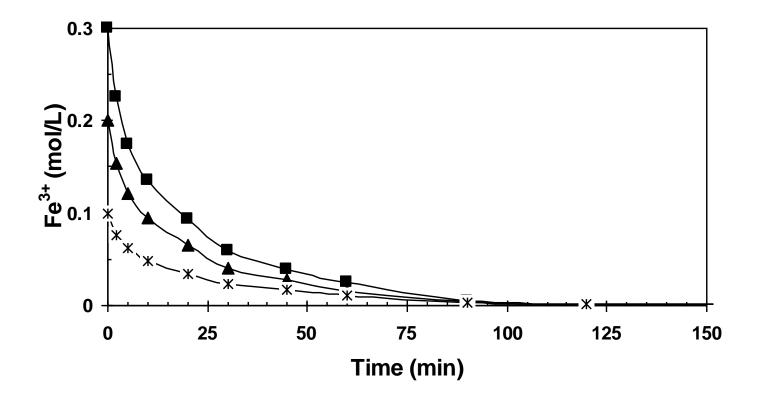
$$T = 85^{\circ}C$$
, $C_{0Fe(III)} = 0.2 \text{ mol/L}$



The effect of the zinc sulphide concentration on the leaching kinetics.

Experimental results

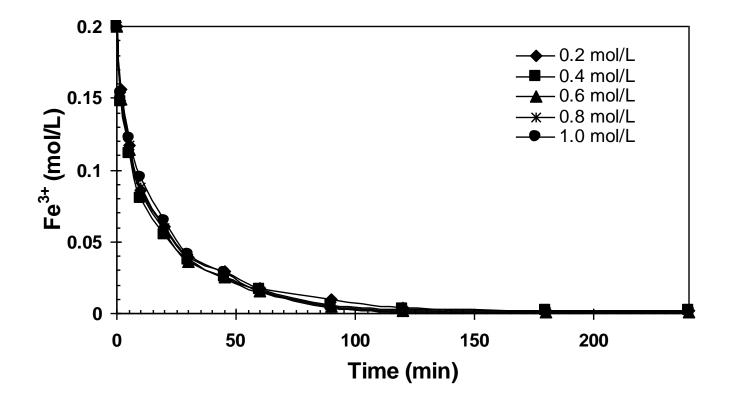
 $T = 95^{\circ}C$, Sphalerite : $Fe^{3+} = 1.1:1$



The effect of the ferric ion concentration on the leaching kinetics.

Experimental results

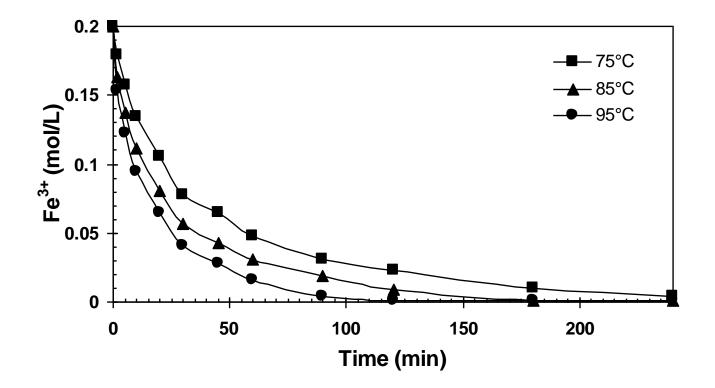
 $T = 95^{\circ}C$, Sphalerite : $Fe^{3+} = 1.1:1$



The effect of sulphuric acid on the leaching kinetics.

Experimental results - Temperature effect

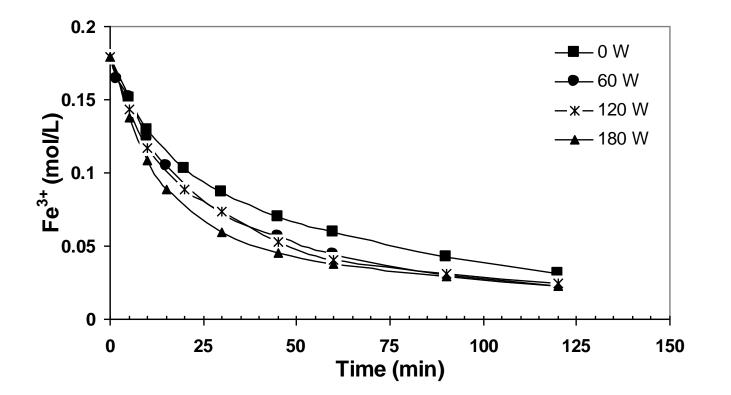
Sphalerite : $Fe^{3+} = 1.1:1$



The effect of temperature on the leaching kinetics.

Experimental results - Ultrasound effect

 $T = 85^{\circ}C$ Stirring rate 350 rpm



The effect of ultrasound on the leaching kinetics.

Reaction mechanism and rate equations

Surface reaction

Stepwise process (first reacts one Fe³⁺, then the second one!)

Rough particles

Three-step surface reaction mechanism

$ZnS(s) + Fe^{3+} \leftrightarrow I_1$		(I)	
$I_1 + Fe^{3+} \leftrightarrow I_2$		(II)	
$I_2 \leftrightarrow S(s) + 2 F e^{2+} + Z$	$2n^{2+}$	(III)	
$ZnS(s) + 2Fe^{3+} \leftrightarrow S(s)$	$) + 2 Fe^{2+} + Zn^{2+}$		$a_1 = k_{+1} c_{FeIII}$
rates of steps (I-III)	$r_1 = a_1 - a_{-1}c_1$	/1	$a_{-1} = k_{-1}$ $a_{2} = k_{+2}c_{FeIII}$
	$r_2 = a_2 c_{I1} - a$	$c_{-2}c_{I2}$	$a_{-2} = k_{-2}$
	$r_3 = a_3 c_{12} - a_2$	_3	$a_{3} = k_{+3}$
	5 - 5 12	-3	$a_{-3} = k_{-3}c_{FeIII}^2c_{ZnII}$

 c_{II} , c_{I2} and c_{I3} = surface concentrations of the intermediates.

Development of rate equations

Pseudo-steady state hypothesis

$$r_1 = r_2 = r_3 = r$$

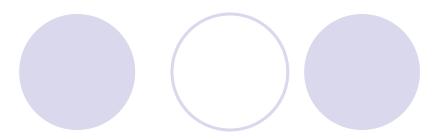
$$r = \frac{a_1 a_2 a_3 - a_{-1} a_{-2} a_{-3}}{a_{-1} a_{-2} + a_{-1} a_3 + a_2 a_3}$$

Back-substitution of $a_1 \dots a_{-3}$ gives

$$r = \frac{k_{+1}k_{+2}k_{+3}c_{FeIII}^{2} - k_{-1}k_{-2}k_{-3}c_{FeII}^{2}c_{ZnII}}{D} \qquad D = k_{-1}k_{-2} + k_{-1}k_{+3} + k_{+2}k_{+3}c_{FeIII}$$

$$r = \frac{k(c_{FeIII}^2 - c_{FeII}^2 c_{ZnII} / K)}{D}$$

Rate equations



Final form

$$r = \frac{k_1 c_{FeIII}^2}{\beta + c_{FeIII}}$$

where
$$\beta = (k_{-1}k_{-2} + k_{-1}k_{+3})/(k_{+2}k_{+3})$$

An alternative rate equation

$$r = \frac{k_1 c_H c_{FeIII}^2}{\beta c_H + c_{FeIII}}$$

NOT VALID FOR THIS CASE!

Area & Shape factor

Development of a general approach

The surface area (A) can be expressed with a generalized equation

$$A = \frac{aM}{\rho_P R_0} n_0^x n^{1-x}$$

n = amount of solid n_0 = initial amount of solid Shape factor (a=1/x)

$$a = \frac{A_P}{V_P} R_0$$
 $a / R_0 = \frac{\sigma m_{0P}}{V_{0P}} = \sigma \rho_P$ $A = \sigma M n_0^{1/a} n^{1/a} n^{1/a}$

Area & Shape factor

Geometry	Shape factor (a)	X	1- x	
Slab	1	1	0	
Cylinder	2	1/2	1/2	
Sphere	3	1/3	2/3	
Irregular,	high value	0	1	
'rough' particle		č	-	

Reaction order can vary between 0 and 1!

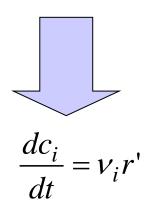
Mass balance for batch reactor

 $\frac{dc_{ZnS}}{dt} = \frac{v_{ZnS}\sigma M}{x_{0ZnS}}c_{ZnS}r$

 $\frac{dc_{FeIII}}{dt} = \frac{v_{FeIII} \sigma M}{x_{0ZnS}} c_{ZnS} r$

$$r' = \frac{\gamma e^{-E_a / RT} c_{ZnS} c_{FeIII}^{2}}{\beta + c_{FeIII}}$$

, where $\gamma = (k_1 \sigma M / x_{0ZnS})$



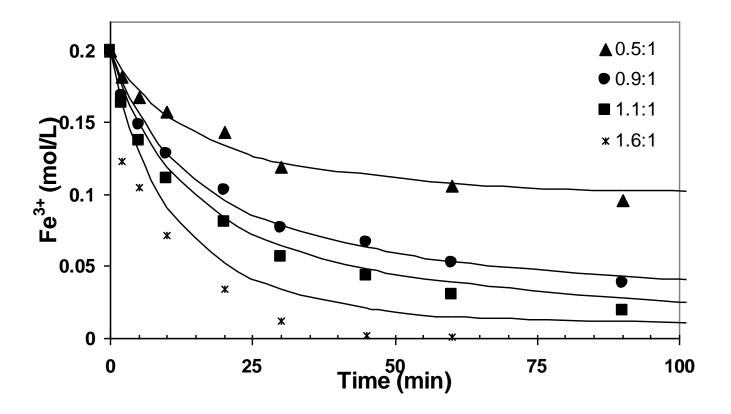
Parameter estimation

Nonlinear regression applied on intrinsic kinetic data

Estimate	ed Parameter	Parameter value	Est. Std. Error %
γ	(L / mol min)	0.331	4.5
Ea	(J / mol)	53200	4.8
β	(mol / L)	0.2	24.9

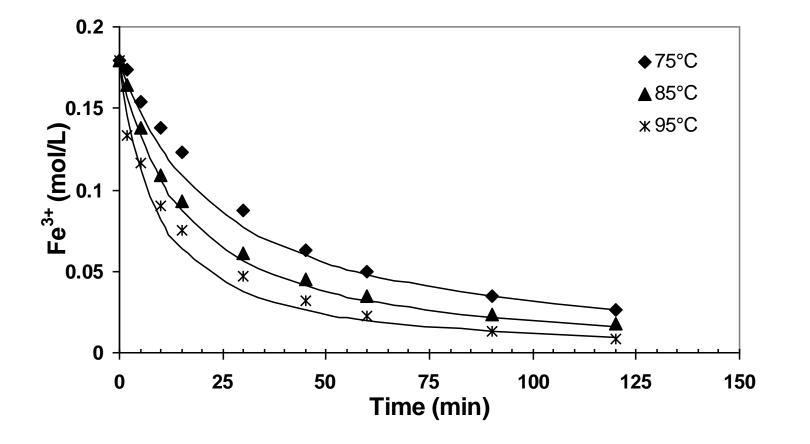
Intrinsic kinetics - Model fit

 $T = 85^{\circ}C$



The effect of the ratio sphalerite : FeIII on the kinetics

Intrinsic kinetics - Model fit



Temperature effect on the kinetics.

Mass transfer limitations in Batch reactor

$$N_{Li}{}^{s}A + v_{i}rA = 0$$

where $r_i = v_i r$ The mass transfer term (N_{Li}^{s}) is described by Fick's law

$$k_{Li}(c_i - c_i^*) = \frac{-\nu_i k_1 c_i^{*2}}{\beta + c_i^*} \qquad \beta' = \beta/c_i, \ \gamma' = (-\nu_i k_1 c_i/k_{Li}), \ y = c_i^*/c_i$$

The solution becomes

$$c_i * / c_i = \frac{2\beta'}{\sqrt{(\beta'-1)^2 + 4(\gamma'+1)\beta'} + \beta'-1} \qquad \qquad r = \frac{k_1 c_{FeIII}}{\beta + c_{FeIII}} * \frac{k_2^2}{\beta + c_{FeIII}} * \frac{k_1 c_{FeIII}}{\beta + c_{FeIII}} * \frac{k_2^2}{\beta + c_{FeII}} * \frac{k_2^2}{\beta + c_{FeII}} * \frac{k_2^2}{\beta + c_{FeI$$

Liquid-solid mass transfer coefficient

General correlation

$$Sh = a + b \operatorname{Re}^{1/2} Sc^{1/3}$$
$$\operatorname{Re} = \left(\frac{\varepsilon d^4}{\upsilon^3}\right)^{1/3}$$
$$Sc = \upsilon / D_i$$
$$Sh = k_{Li} d / D_i$$

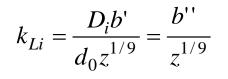
$$k_{Li} = \frac{D_i}{d} \left(a + b \left(\frac{\varepsilon d^4}{\upsilon^3} \right)^{1/6} \left(\frac{\upsilon}{D_i} \right)^{1/3} \right) \qquad \qquad k_{Li} = \frac{D_i}{d_0 z^{1/3}} \left(a + b \left(\frac{\varepsilon d_0^4 z^{4/3}}{\upsilon^3} \right)^{1/6} \left(\frac{\upsilon}{D_i} \right)^{1/3} \right)$$

where $z=c_{ZnS}/c_{0ZnS}$. The index (i) refers to Fe(III) and Fe(II)

Correlations in rate equation

$$k_{Li} = \frac{D_i}{d_0 z^{1/3}} \left(2 + b' z^{2/9} \right) \qquad b' = b(\varepsilon d_0^4 / \upsilon^3)^{1/6} (\upsilon / D_i)^{1/3}$$

IF $b'z^{2/9} >> 2$ under stirring,



$$\gamma' = -v_{FeIII} x_{0ZnS} \gamma c_{FeIII} z^{1/9} / (\sigma Mb''_{FeIII})$$

$$\gamma' = \frac{-v_{FeIII} \gamma c_{FeIII} \omega}{\left(c_{0ZnS} / c_{ZnS}\right)^{1/9}}$$

$$\omega = x_{0ZnS} d_0^{1/3} / (\sigma Mb(\varepsilon / \upsilon)^{1/6} D_{FeIII}^{2/3})$$

The surface concentration:

The rate:

$$c_{FeIII} * = \frac{2\beta c_{FeIII}}{\sqrt{(\beta - c_{FeIII})^2 + 4(\gamma' + 1)\beta c_{FeIII}} + \beta - c_{FeIII}}$$

 $r' = \frac{\gamma c_{ZnS} c_{FeIII}^{*2}}{\beta + c_{FeIII}^{*}}$

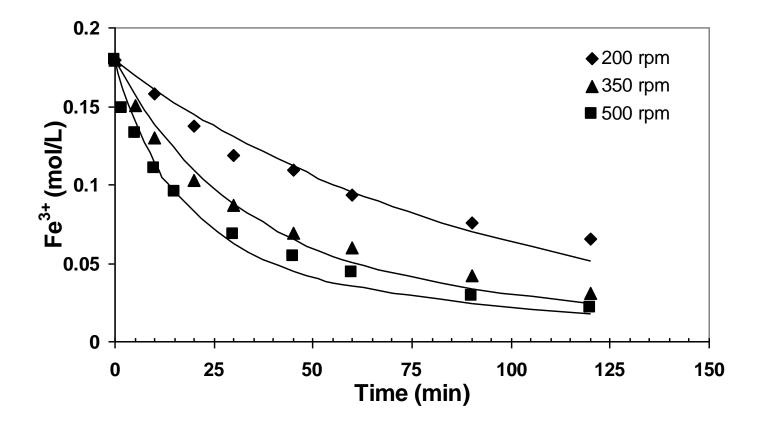
Determination of mass transfer parameter (ω)

Agitation	rate	&	US	effect
0				

 $\omega \pmod{(\text{mol min} / \text{m}^3)}$

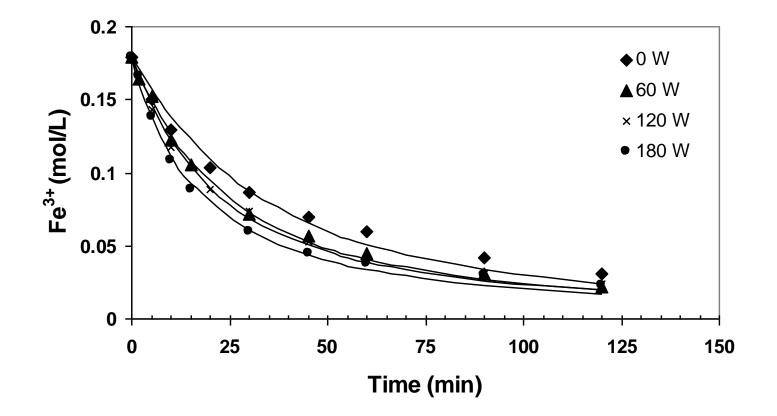
200 rpm		50	
350 rpm		14	
500 rpm		2.4	
350 rpm	US 0 W	14	
350 rpm	US 60 W	6.8	
350 rpm	US 120 W	5.8	
350 rpm	US 180 W	1.67	

Modelling of kinetics and mass transfer

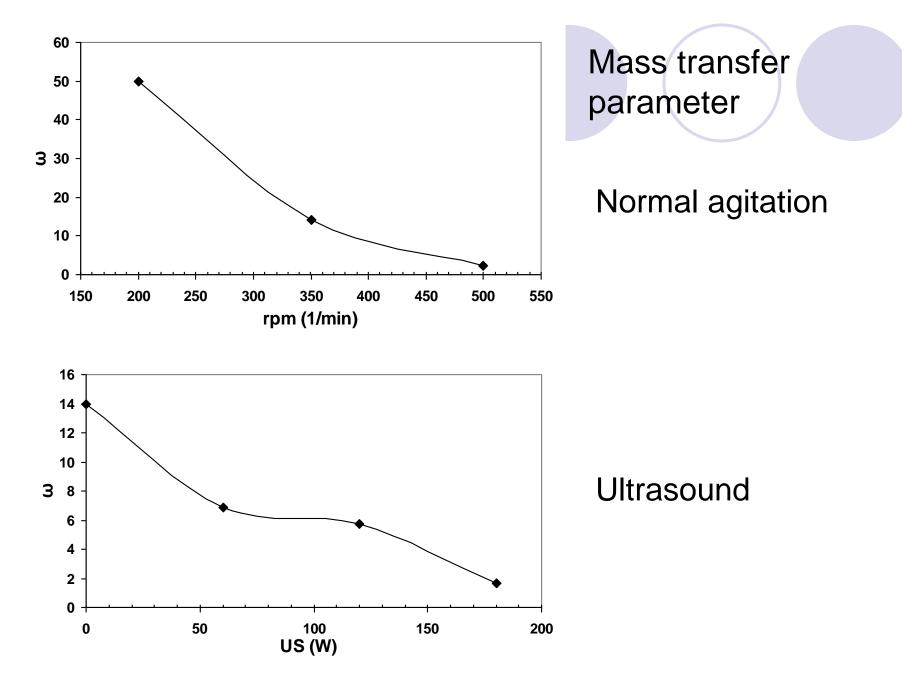


External mass transfer limitations – modelling of individual mass transfer parameters at different agitation rates.

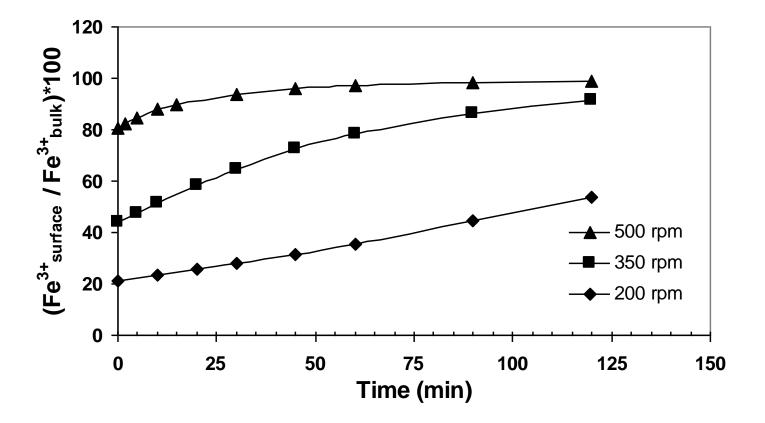
Modelling of kinetics and mass transfer



External mass transfer limitations – modelling of individual mass transfer parameters at different ultrasound inputs.

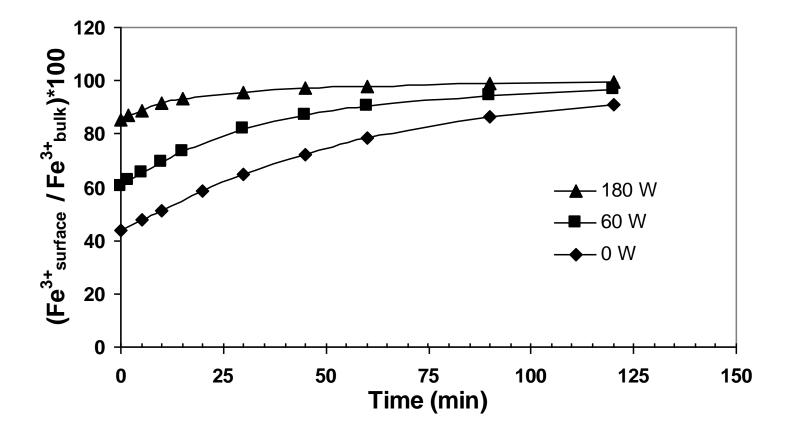


The real impact of mass transfer limitations



The difference in the model based surface concentrations and measured bulk concentrations of Fe3+ at different stirring rates.

The real impact of mass transfer limitations



The difference in the model based surface concentrations and measured bulk concentrations of Fe3+ at different ultrasound inputs.

Conclusions



- A general treatment of smooth, rough and porous surfaces was developed
- The theory of mass transfer was implemented in the model
- Model parameters were estimated
- The model works

Modelling and simulation of porous, reactive particles in liquids: delignification of wood



Tapio Salmi, Johan Wärnå, J.-P. Mikkola, Mats Rönnholm Åbo Akademi Process Chemistry Centre, Laboratory of Industrial Chemistry FIN-20500 Turku / Åbo Finland, Johan.Warna@abo.fi

Typical view of Finland

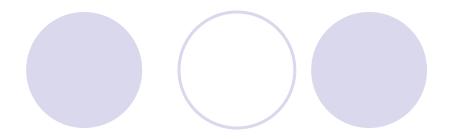




338000 km² of which 70% forest



Papermaking

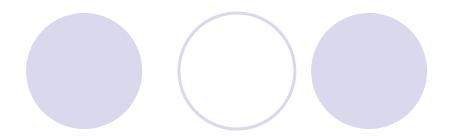


Wood chips

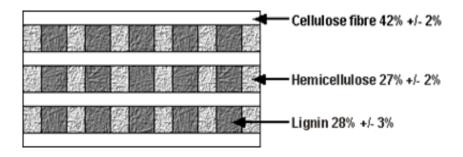
- This is where paper making begins.
- A typical wood chip measures 40 x 25 x 10 mm.

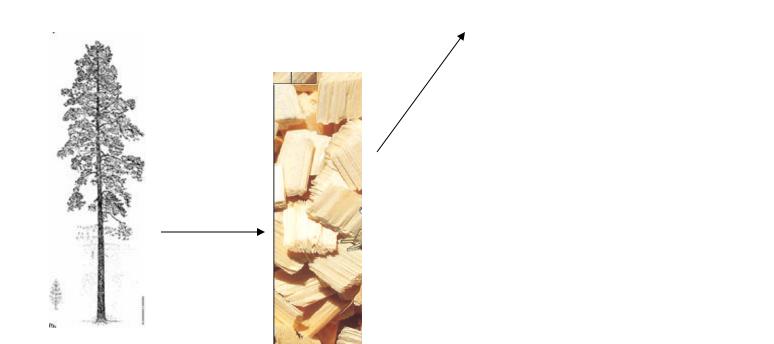


Wood



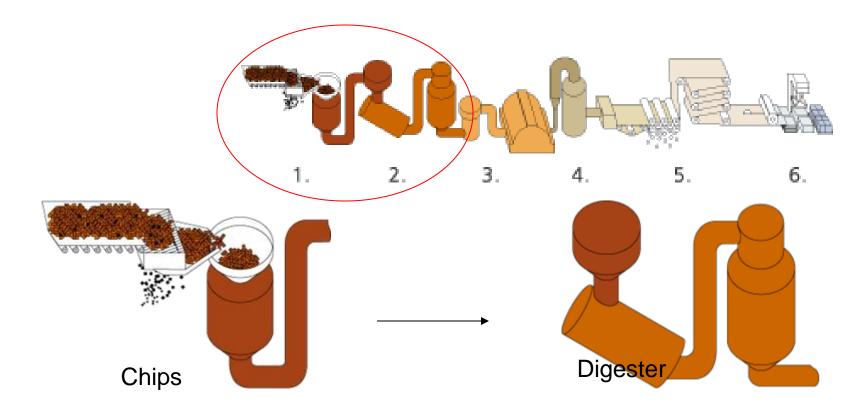
 Each chip comprises water, cellulose wood fibres and the binding agent lignin.





Pulp

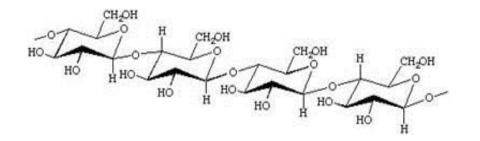
 To make paper, we need to first make pulp, which is the process of breaking the wood structure down into individual fibers



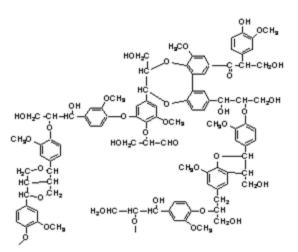
Reactions

The reactions in chemical pulping are numerous. Typical pulping chemicals are NaOH and NaHS

cellulose



Part of Lignin molecule



Overall process:

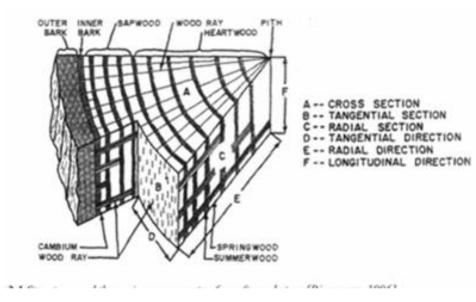
Lignin+Cellulose+Carbohydrates+Xylanes+OH+HS -> Dissolved components

Kinetic modelling of wood delignification

- Purdue model (Smith et.al. (1974) Christensen et al. 1983), 5 pseudocomponents
- Gustafson et al. 1983, 2 wood components Lignin and Carbohydrate, 3 stages
- Andersson 2003, 15 pseudocomponents
- Very few models available!

Wood chip structure

- Wood material is built up of fibres
- We can expect different diffusion rates in the fibre direction and in the opposite direction to the fibres.



Existing models

 The existing models for delignification of wood consider a 1 dimensional case with equal diffusion rates in all directions

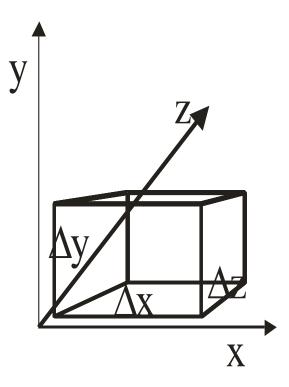
Is a 2- or 3-dimensional model needed ?

Characteristics of our model

- Time dependent dynamic model
- Complex reaction network included
- Mass transfer via diffusion in different directions
- Structural changes of the wood chip included
- All wood chips of equal size
- Perfectly mixed batch reactor assumed

Mathematical model, volume element

 3D –model for a wood chip



$$\overline{\left(N_{ix}A_{yz}\right)_{in}} + \left(N_{iy}A_{xz}\right)_{in} + \left(N_{iz}A_{xy}\right)_{in} + r_{i}^{'}\Delta V = \left(N_{ix}A_{yz}\right)_{out} + \left(N_{iy}A_{xz}\right)_{out} + \left(N_{iz}A_{xy}\right)_{out} + \frac{dn_{i}}{dt}$$



Mass balance for a wood chip

$$\frac{dc_i}{dt} = \frac{D_i}{\varepsilon_p(t)} \left(\varepsilon_x' \frac{d^2 c_i}{dx^2} + \varepsilon_y' \frac{d^2 c_i}{dy^2} + \varepsilon_z' \frac{d^2 c_i}{dz^2} \right) + \frac{r_i'}{\varepsilon_p(t)}$$

Porosity

$$\mathcal{E}_{p}(t) = \sqrt[3]{\mathcal{E}_{x}} \mathcal{E}_{y} \mathcal{E}_{z}$$
 $\mathcal{E}_{x} = \frac{\mathcal{E}_{x}}{\tau_{px}}$

px

Boundary conditions

The concentrations outside the wood chip are locally known $c_{\rm i}{=}c_{\rm Li}$

at the centre of the chip (symmetry)

$$dc_i/dx = dc_i/dy = dc_i/dz = 0$$

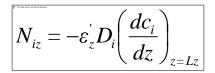
Reactor model



Batch reactor model, ideal flow

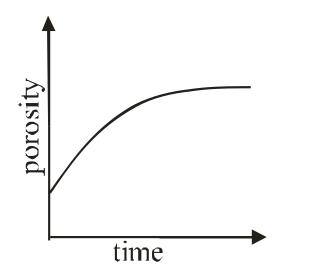
$$\frac{dc_{Li}}{dt} = N_{ix}a_{yx} + N_{iy}a_{xz} + N_{iz}a_{xy} + r_i$$

Fluxes from wood chip



Structural changes of the wood chip

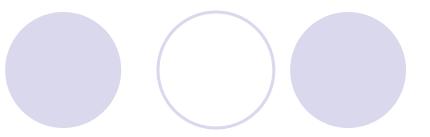
Generally one can state that the porosity of the chip increases during the process, since lignin and hemicelluloses are dissolved



Change of porosity as a function of the lignin conversion

$$\boxed{\begin{array}{l} & \left[\eta_{l} = \frac{c_{0l} - c_{l}}{c_{0l}} = 1 - \frac{c_{l}}{c_{0l}} \right]} \\ & \left[\epsilon_{p} = \epsilon_{0 p} + \left(\epsilon_{\infty} - \epsilon_{0 p} \right) \left(1 - \left(1 - \eta_{l} \right)^{\alpha'} \right) \right] \end{array}}$$

Kinetic models



Andersson model, 12 wood pseudocomponents

$$r_i = k_1 \left(c_{OH}^{\alpha} c_{HS}^{\beta} + k_2 \right) W_i$$

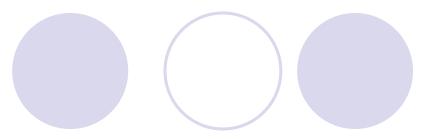
Purdue model (Christensen et al), 5 wood pseudocomponents

$$\frac{-dC}{dt} = \left[k_i^{\dagger} \cdot \left(OH^{-}\right) + k_i^{\dagger} \cdot \left(OH^{-}\right)^a \cdot \left(HS^{-}\right)^b\right] \cdot \left(C - C_0\right)$$

Gustafsson model, 2 wood components, 3 stages
Initial stage, >22% Lignin,
Bulk stage , 22% > Lignin > 2%
Residual stage < 2% Lignin</th> $\frac{dL}{dt} = 36.2 \cdot T^{0.5} \cdot e^{\frac{-480769}{T}} \cdot L$ $\frac{dC}{dt} = 2.53 \cdot [OH]^{0.11} \cdot \frac{dL}{dt}$ $\frac{dL}{dt} = 36.2 \cdot T^{0.5} \cdot e^{\frac{-480769}{T}} \cdot L$ $\frac{dL}{dt} = 2.53 \cdot [OH]^{0.11} \cdot \frac{dL}{dt}$

$$\frac{dL}{dt} = e^{19.64 - \frac{10804}{T}} \cdot [OH]^{0.7} \cdot L$$

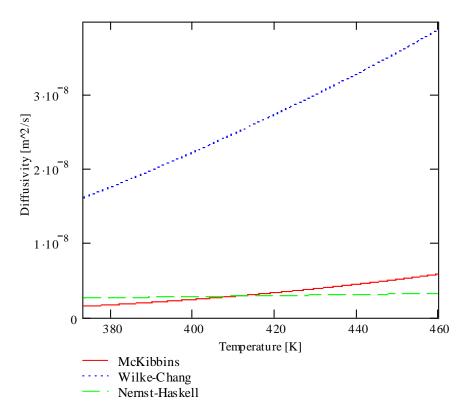
Diffusion models



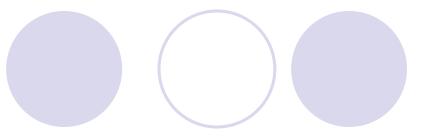
McKibbins $D_{NaOH,H_2O} = 5.667 \cdot 10^{-8} \cdot \sqrt{T} \cdot e^{\frac{-4870}{1.9872T}}$ Wilke-Chang $D_{AB} = \frac{7.4 \cdot 10^{-12} \cdot \sqrt{\phi \cdot M_B} \cdot T}{\mu_B \cdot V_A^{0.6}}$

Nernst-Haskel (infinite dillution)

$$D^{\circ} = 8.931 \cdot 10^{-14} \cdot T \cdot \left(\frac{\lambda_{+}^{0} \cdot \lambda_{-}^{0}}{\lambda_{+}^{0} + \lambda_{-}^{0}}\right) \cdot \left(\frac{z_{+} + z_{-}}{z_{+} \cdot z_{-}}\right)$$



Kappa number



The progress of delignification is by pulp professionals described by the Kappa number

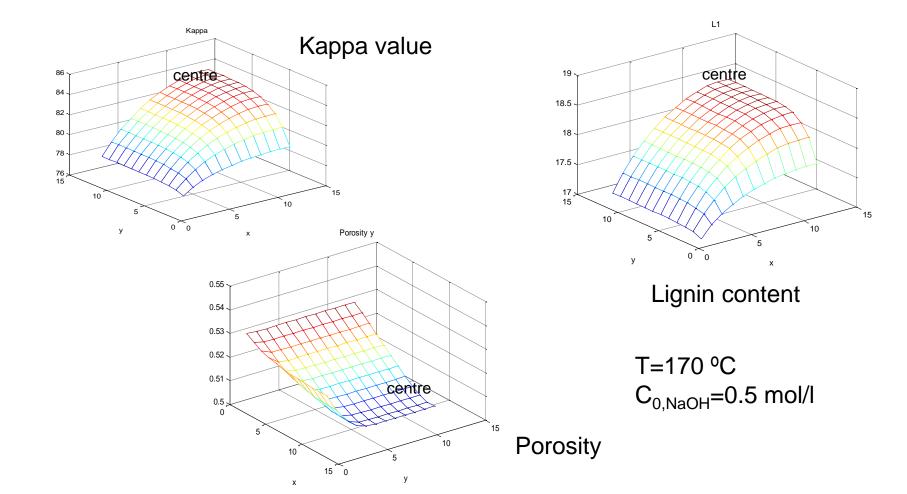
$$\kappa = 500 \frac{L}{L + CH} + 5$$

L = Lignin on wood, CH = Carbohydrates on wood

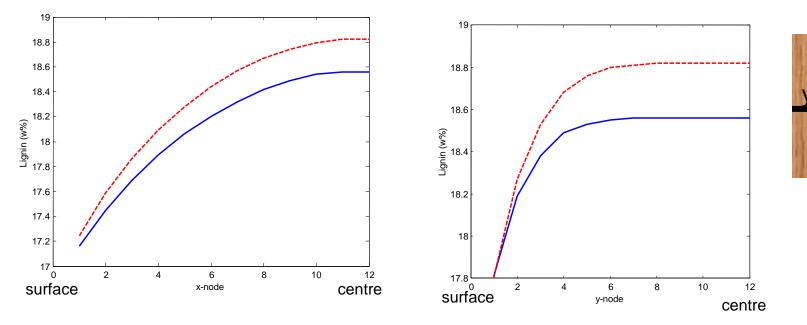
Numerical approach

- Discretizing the partial differential equations (PDEs) with respect to the spatial coordinates (x, y, z).
- Central finite difference formulae were used to approximate the spatial derivatives
- Thus the PDEs were transformed to ordinary differential equations (ODEs) with respect to the reaction time with the use of the powerful finite difference method.
- The created ODEs were solved with the backward difference method with the software LSODES

Simulation results, profiles inside wood chip

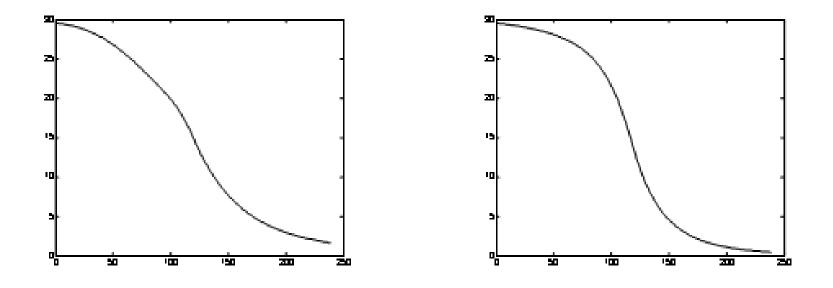


The impact of 2-D model



Red line, different diffusion rates in x and y directions Blue line, same diffusion rates in x and y direction (Andersson kinetic model)

Content of lignin on wood as a function of reaction time



Lignin concentration (w-%) in wood chip as a function of reaction time (min) with Andersson kinetic model (left) and Purdue kinetic model (right).

Simulation software

- 2-D model for a wood chip in a batch reactor
- Different kinetic and diffusion models available
- Structural change model included (porosity)
- Dynamic model
 - all results can be presented as a function of reaction time
- Temperature and alkali concentrationprofiles can be programmed as a function of reaction time

Conclusions

- A general dynamic model and software for the description of wood delignification
- Solved numerically for example cases, which concerned delignification of wood chips in perfectly backmixed batch reactors.
- Structural changes and anisotropies of wood chips are included in the model.
- The software utilizes standard stiff ODE solvers combined with a discretization algorithm for parabolic partial differential equations.
- Example simulations indicated that the selected approach is fruitful, and the software can be extended to continuous delignification processes with more complicated flow patterns.

Thank you!

